

Nanotechnologies and new materials

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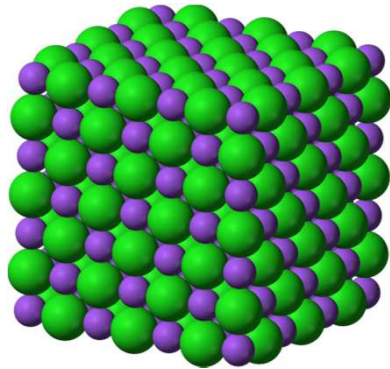


Summary

- **2D materials**
- **Graphene: Properties**
 - Exfoliation**
 - CVD growth - Transfer**
 - Electronic Structure**
- **2D heterostructures**
- **Conclusions**

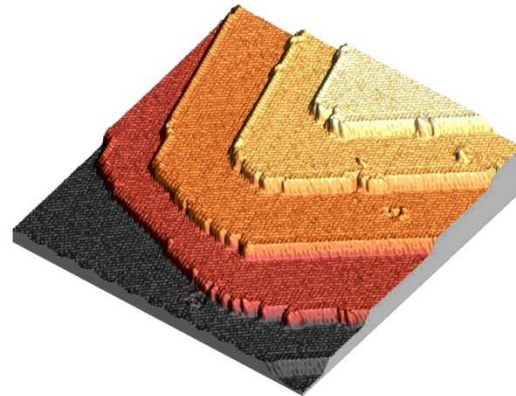
0D, 1D, 2D and 3D materials

3D

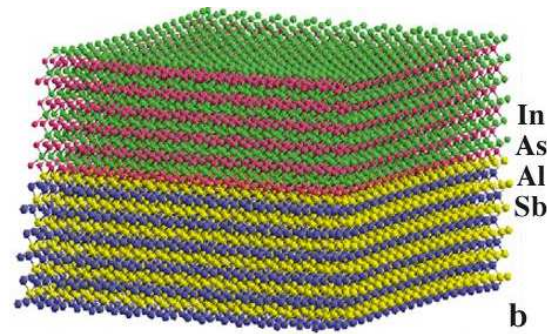


bulk crystals

2D

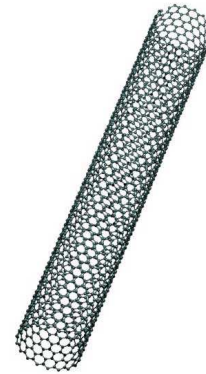


ultra-thin films



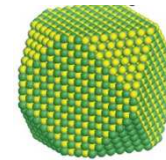
quantum wells

1D



nanotubes
nanowires

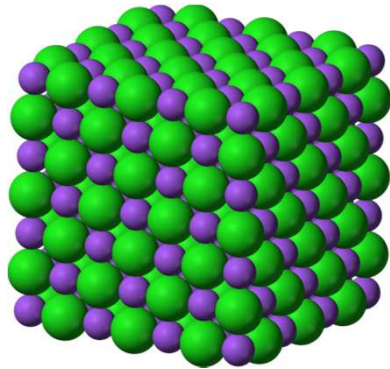
0D



quantum dots

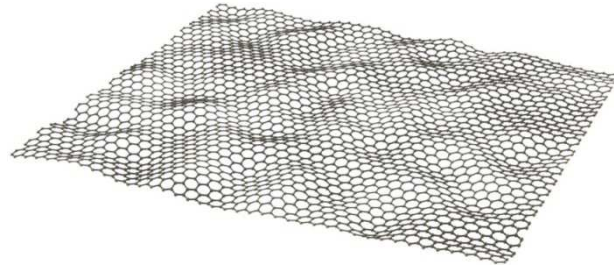
0D, 1D, 2D and 3D materials

3D



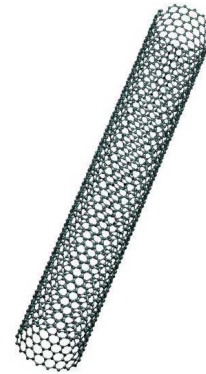
bulk crystals

2D



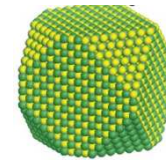
graphene

1D



nanotubes
nanowires

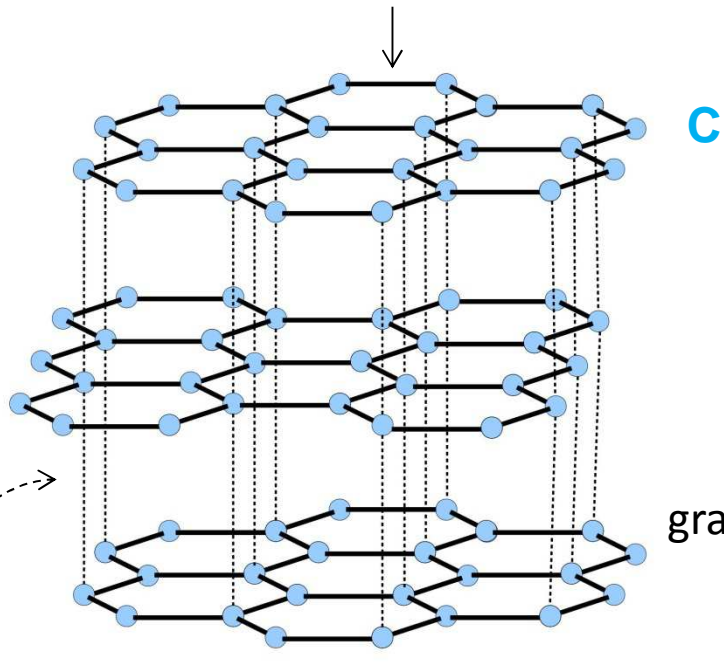
0D



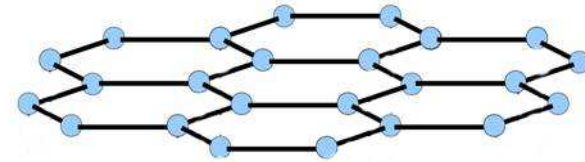
quantum dots

Graphene

strong in-plane covalent bond



weak inter-plane *van der Waals* bonds



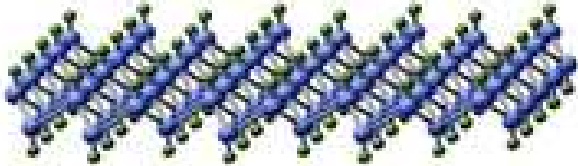
graphene

2D Materials

2D



Graphene



Graphane



h-BN



NbSe₂



MoS₂

etc.

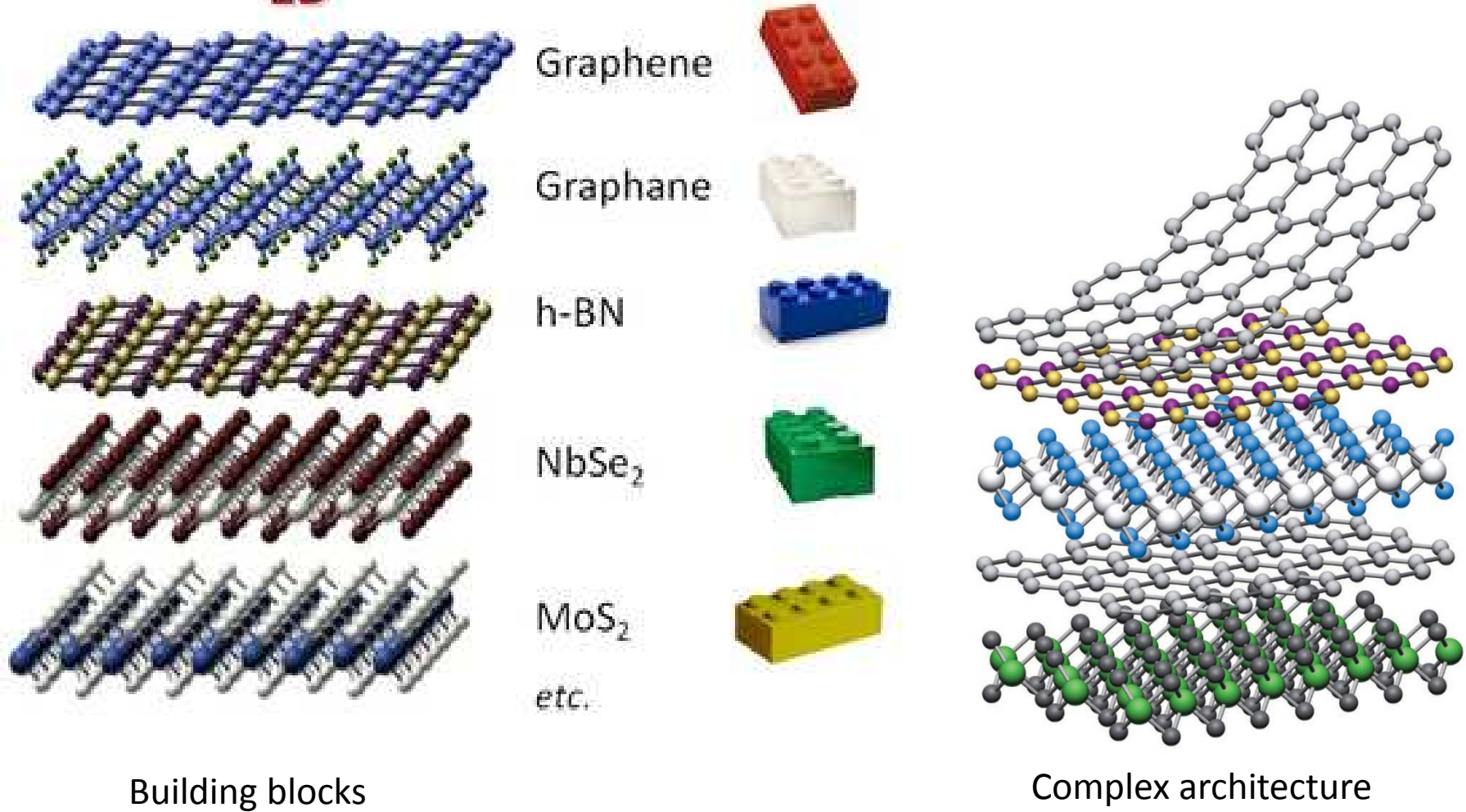
Usually 2D materials have a 3D analog which are lamellar solids

They can be isolated as free-standing one-atom or few-atoms thick layers and can exist without a substrate

They exhibit optical and electronic properties different from their 3D analogs

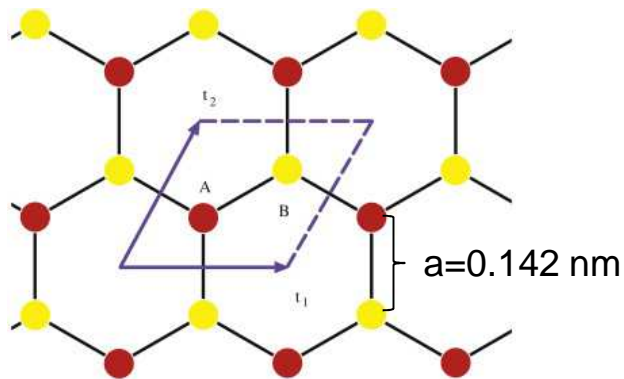
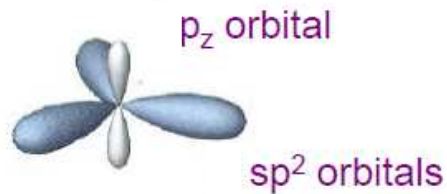
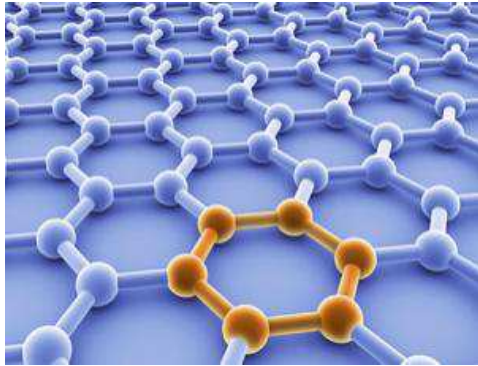
Materials in the Flatland

2D

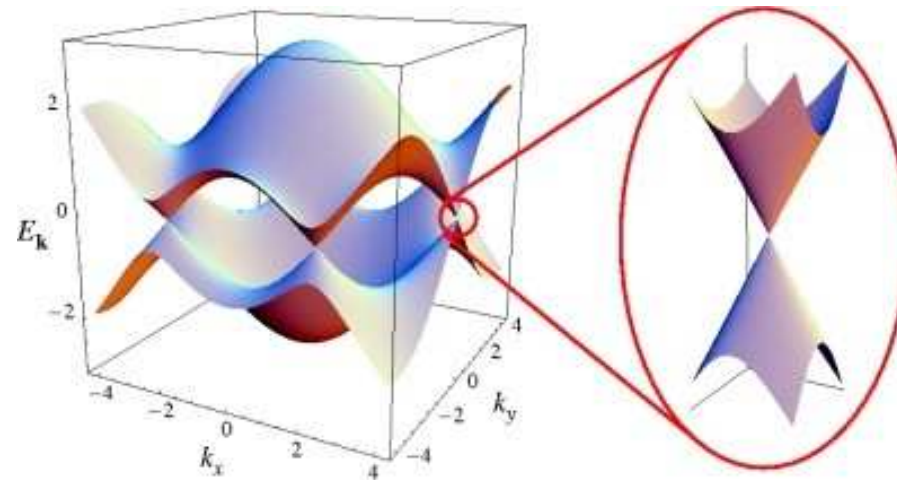


New materials create new challenges in condensed matter research.

Monolayer graphene properties



semi-metal or zero-gap semiconductor

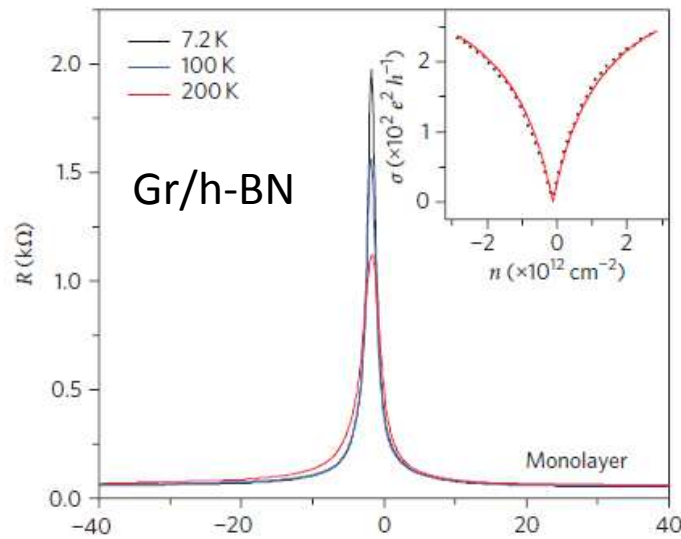
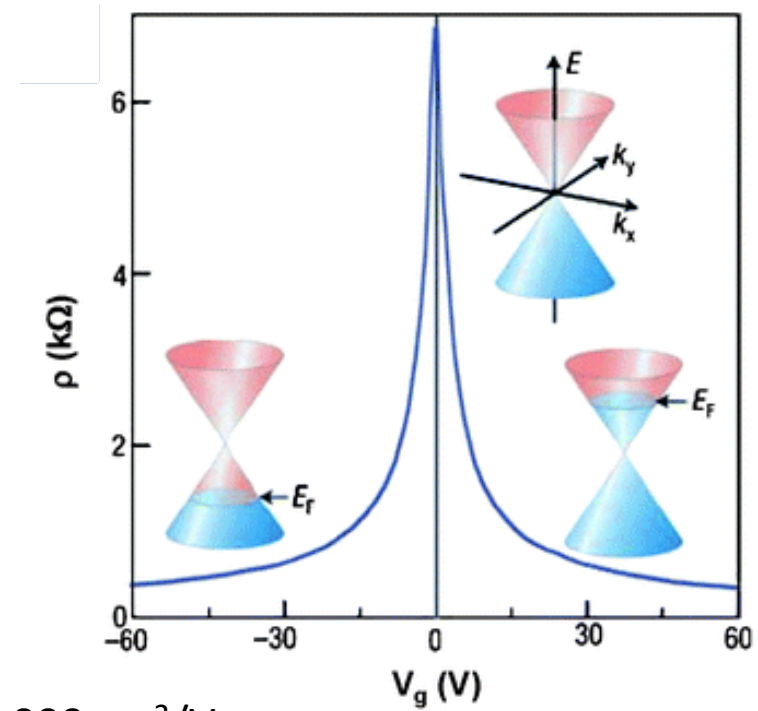
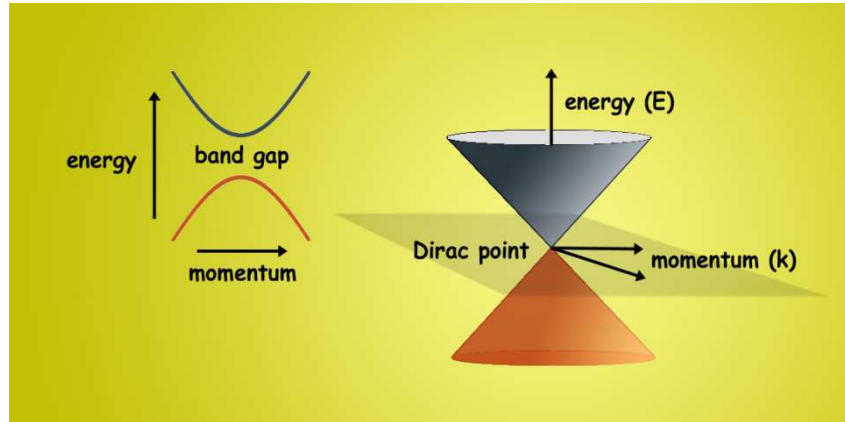


at the Dirac points the dispersion is linear and electrons and holes behave like relativistic particles with Fermi velocity $v_F \sim 10^6$ m/s

transport is ambipolar

graphene lacks a bandgap around the Fermi level

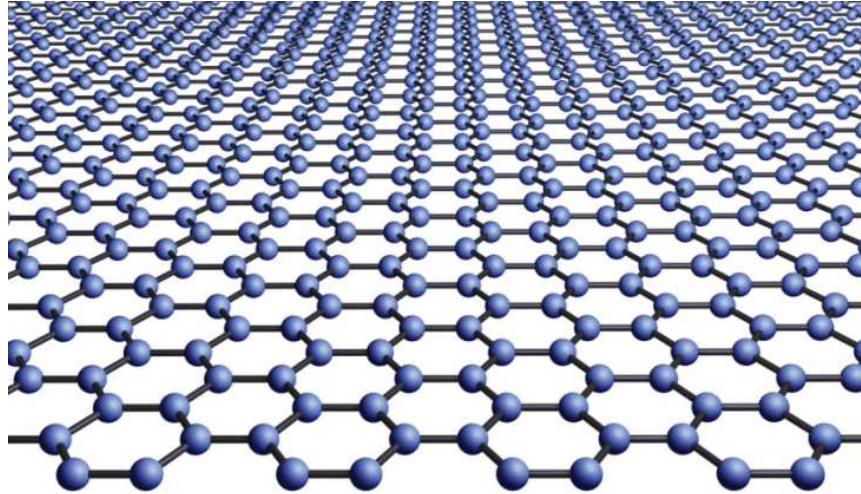
Monolayer graphene properties



$$\mu_C \approx 60.000 \text{ cm}^2/\text{Vs}$$



Graphene properties



Graphene:

is a semimetal but conducts as the best metals

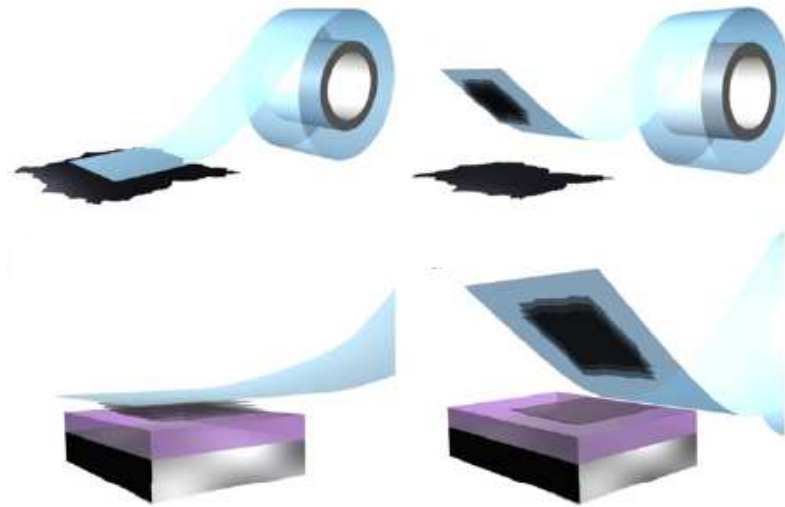
transport can be modulated (it can be switched ON and OFF)

possesses record electron and hole mobilities ($> \times 100$ than Si)

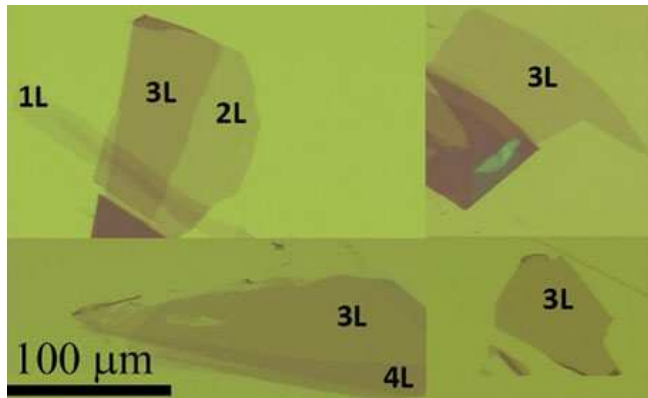
allows very high current densities ($\sim 4-8 \text{ mA}/\mu\text{m}$, $10^9 \text{ A}/\text{cm}^2$)

- is the strongest material ($> 5 \times$ stainless steel and much lighter)
- is flexible
- is a super heat-conductor ($> \times 40$ than Si)
- is chemically inert
- is biocompatible

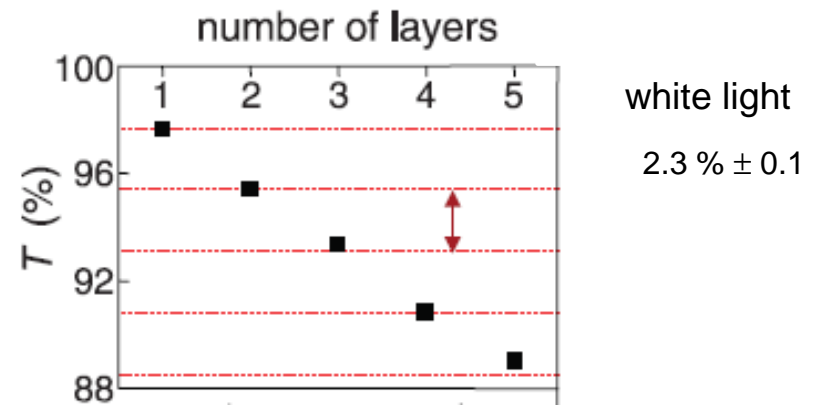
Mechanical exfoliation



Novoselov et al
Phys. Scr. T146 014006 2012

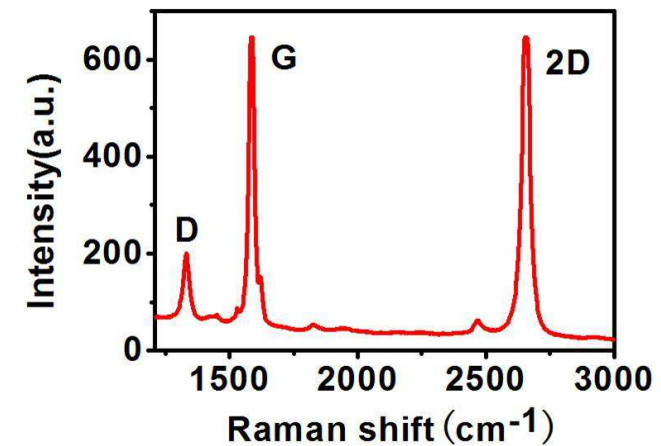
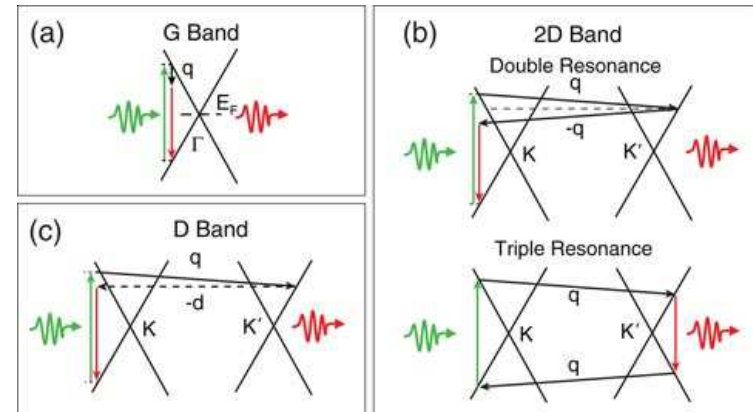
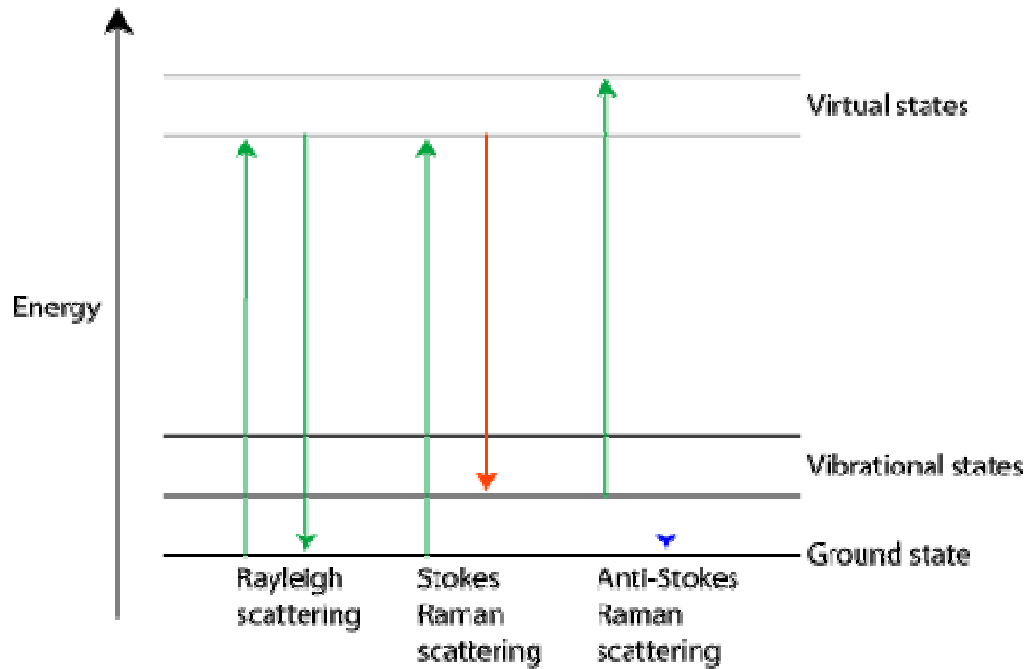
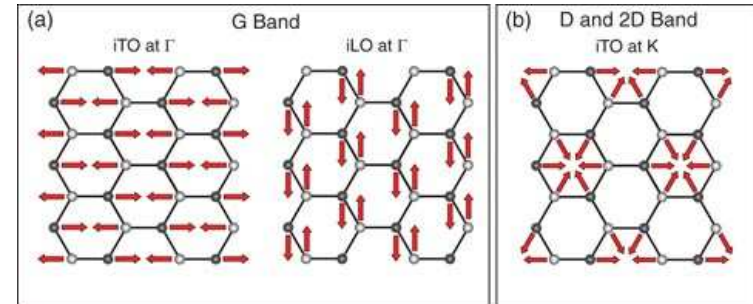
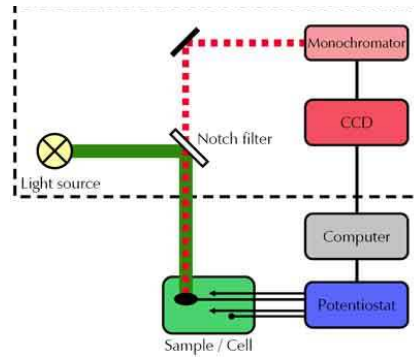
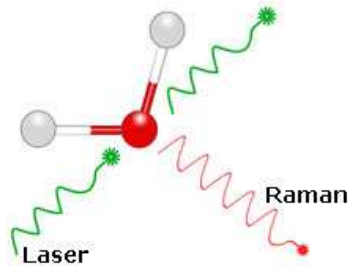


<http://emps.exeter.ac.uk/>

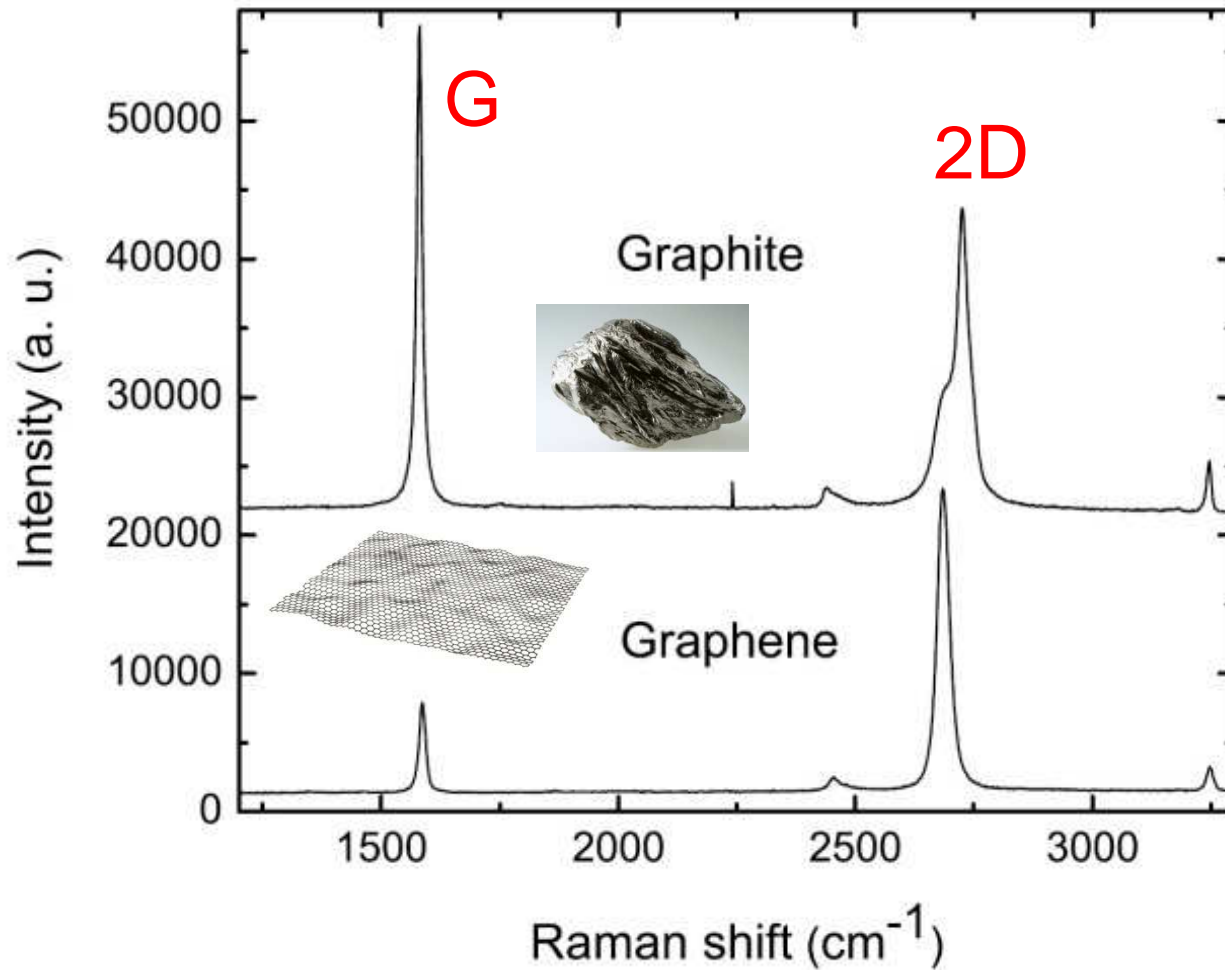


Nair et al. Science 320, 1308 2008

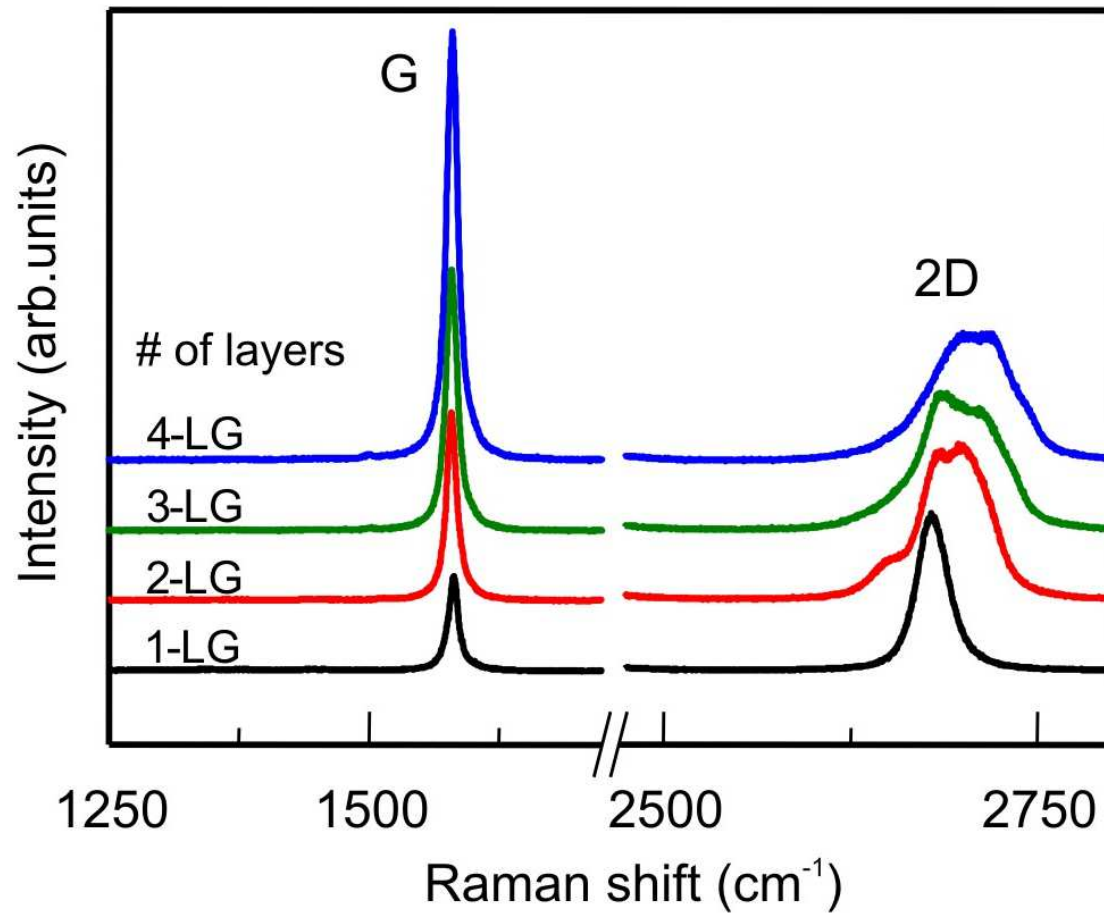
Raman spectroscopy



Raman spectroscopy of graphene

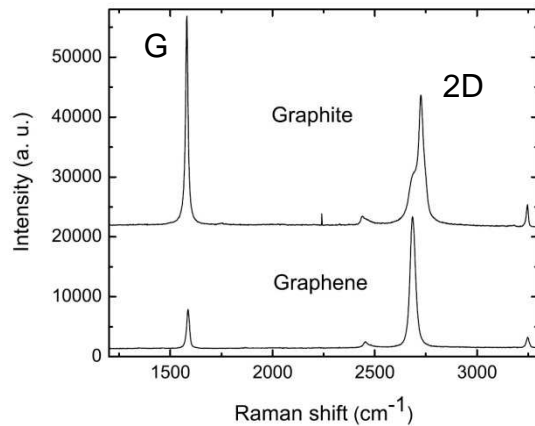


Raman spectroscopy of graphene

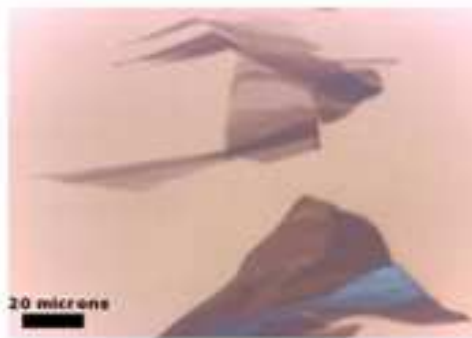
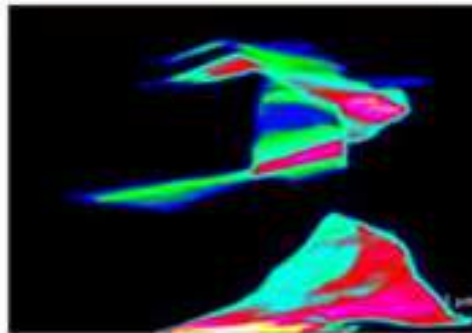


Production of graphene monolayers

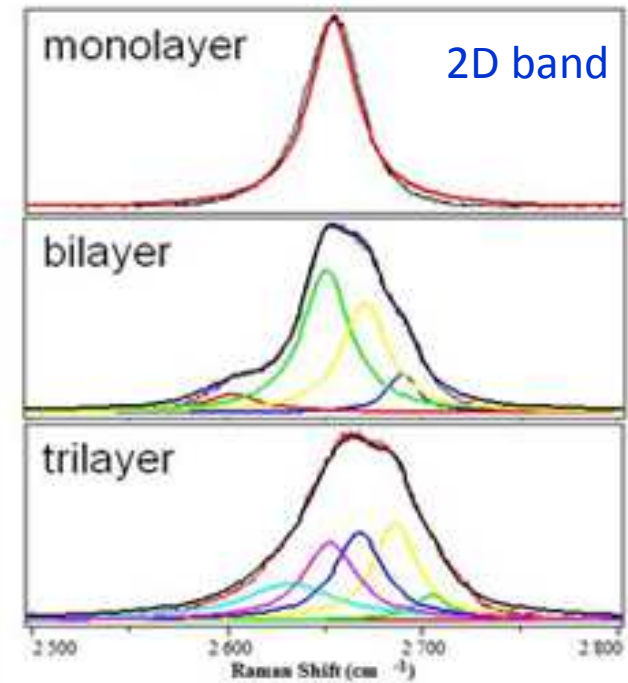
Raman spectroscopy



G band intensity Raman image



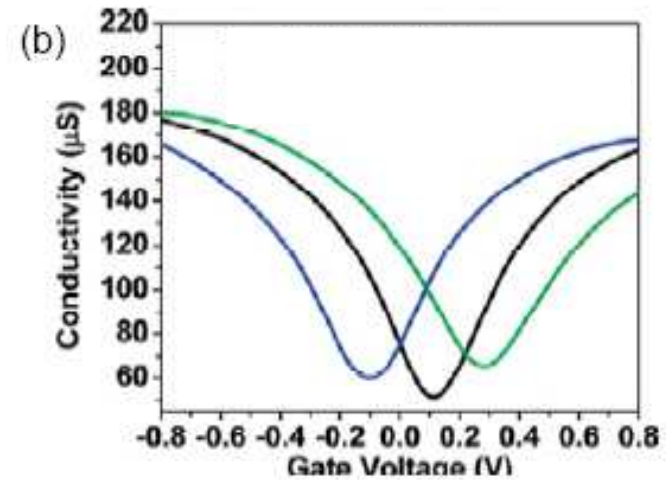
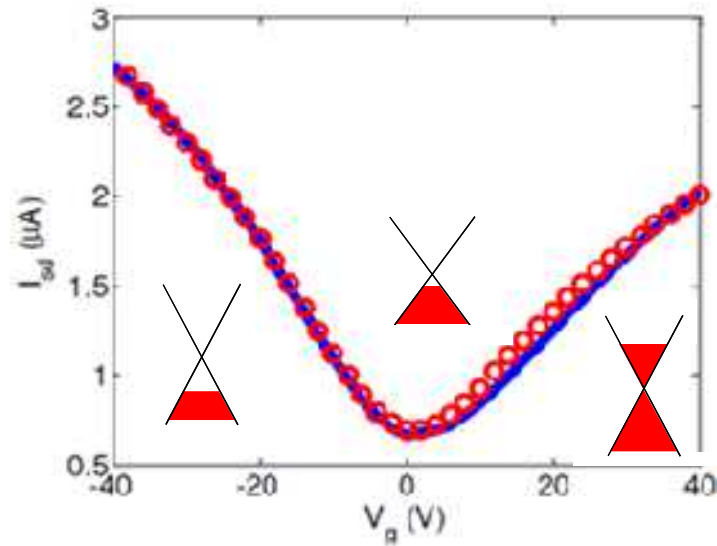
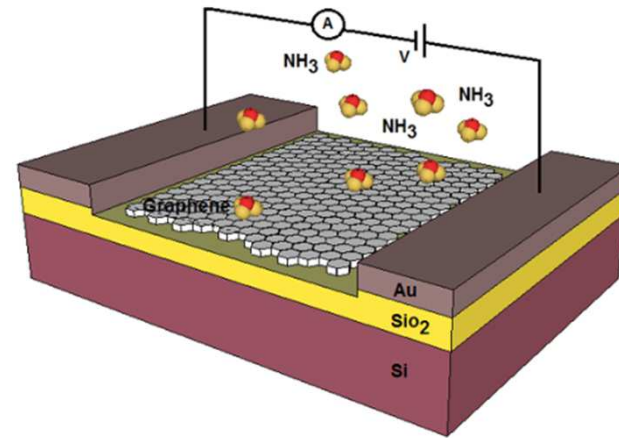
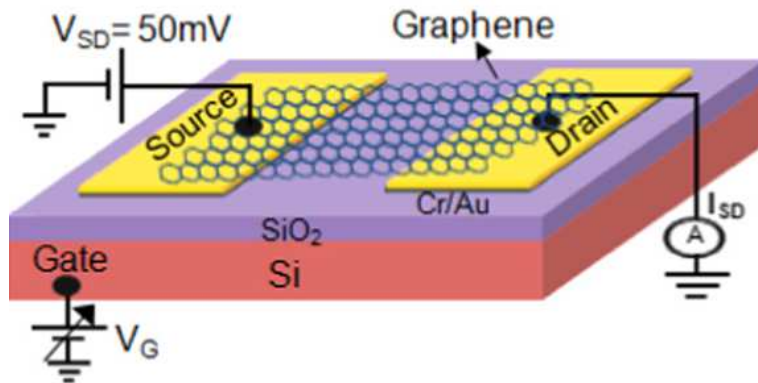
optical image



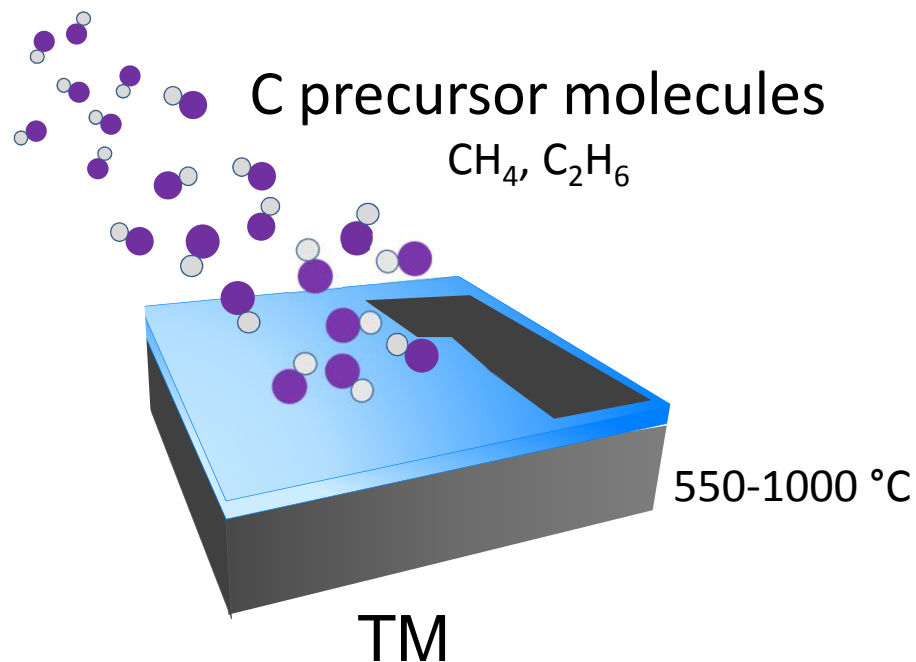
<http://www.horiba.com>

Graphene-based devices

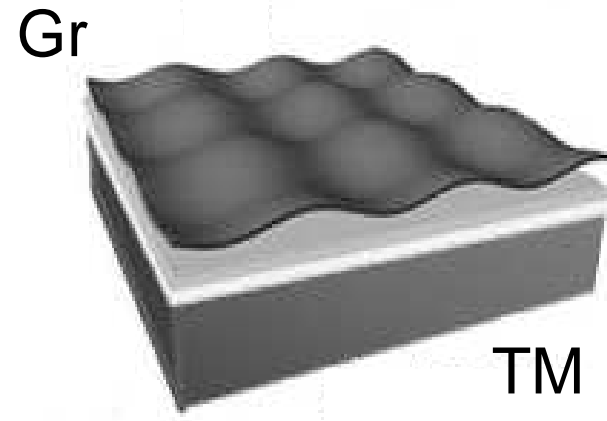
Field effect transistor



Epitaxial graphene on TM metals



Chemical Vapour Deposition

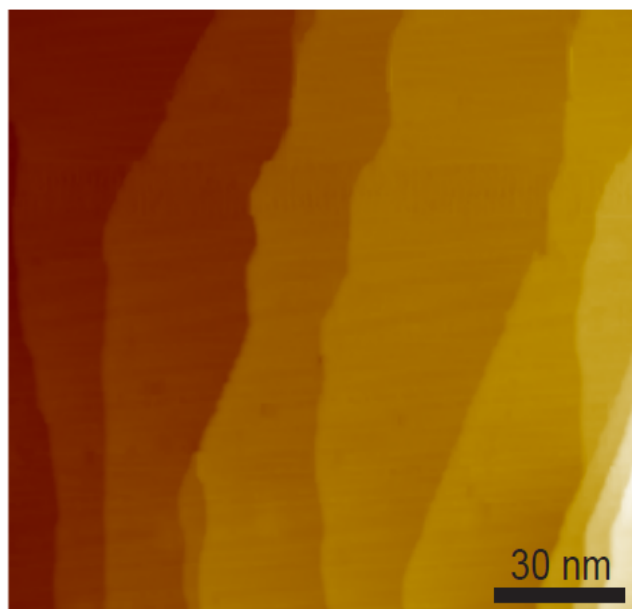


(Ir, Ru, Pt, Re, Rh, Ni, Fe, Cu, PtRh, NiAl,)

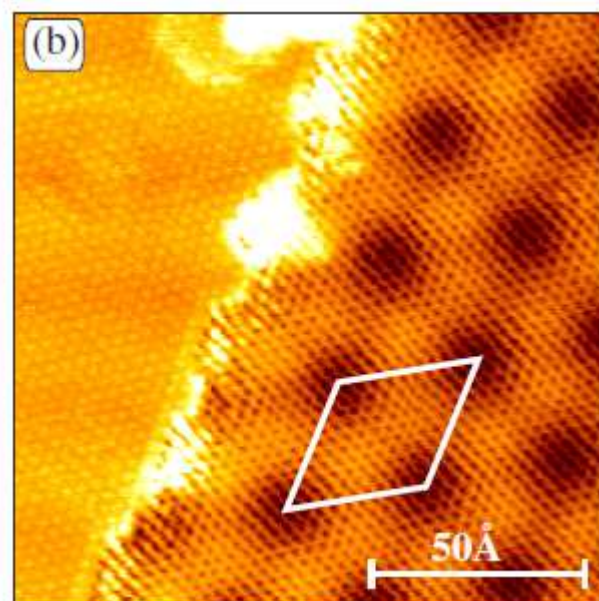
Large area graphene
Self-limiting growth
Low defect density

Epitaxial graphene on TM metals

Scanning Tunneling Microscopy

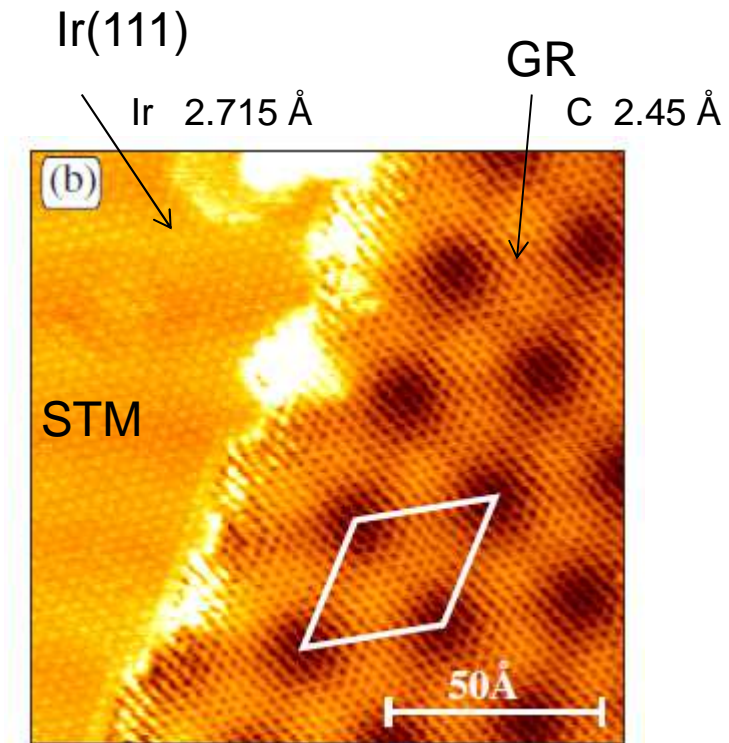


Gr/Ir(111)



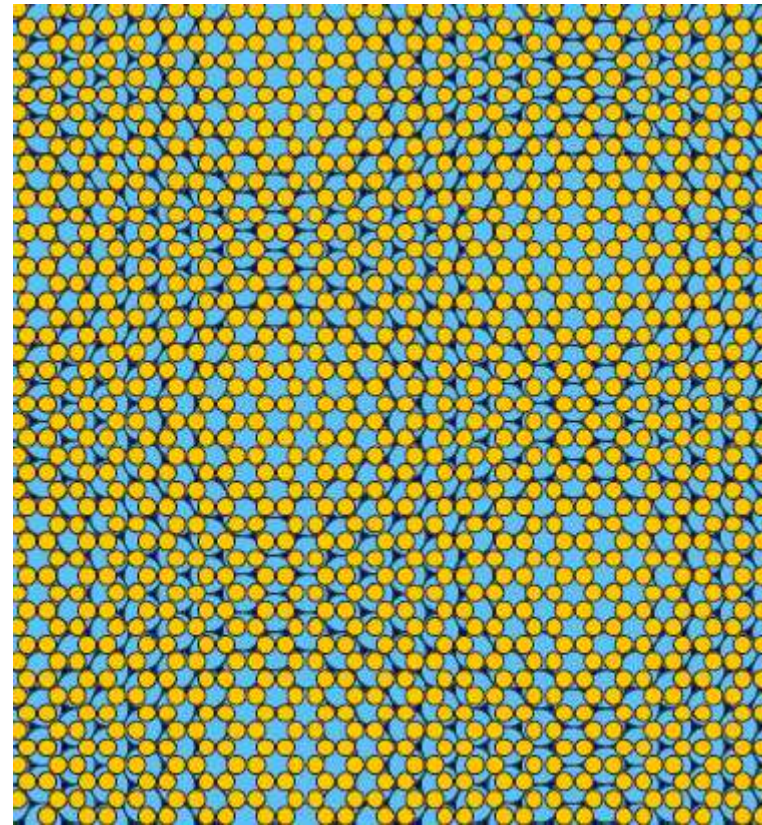
Gr/Ir(111)

Moiré pattern in epitaxial graphene



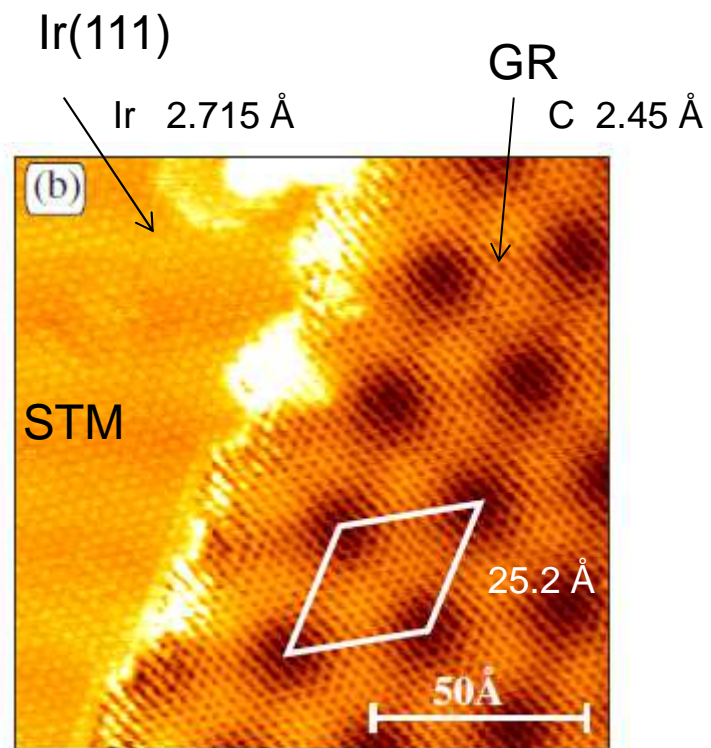
N'Diaye et al PRL 97, 215501 (2006)

Gr/Ir(111)

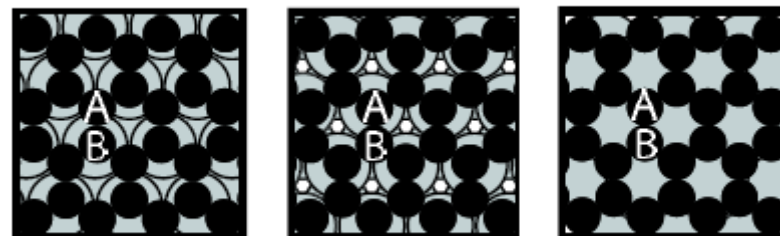
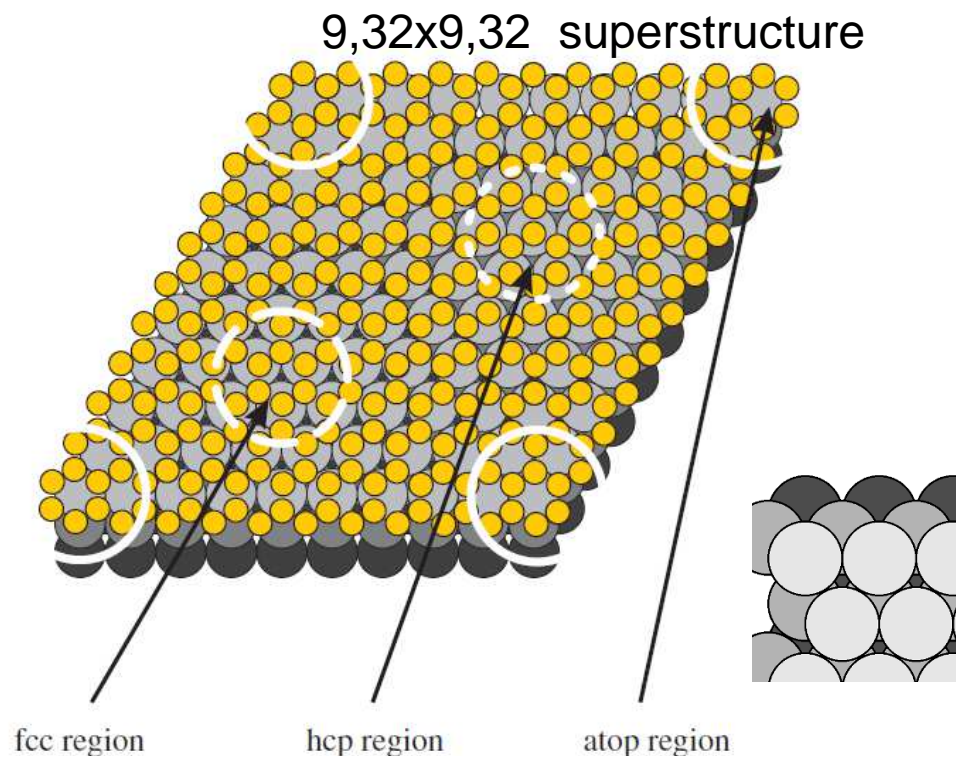


Graphene on Ir(111)

Graphene on Ir(111)



N'Diaye et al PRL 97, 215501 (2006)

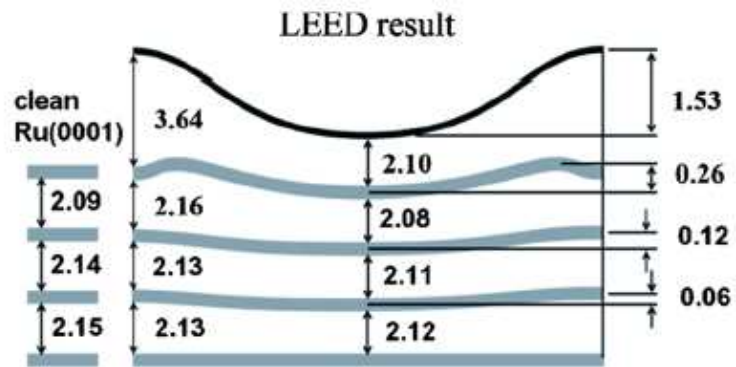


C ●

N'Diaye et al NJP 10 (2008) 043033

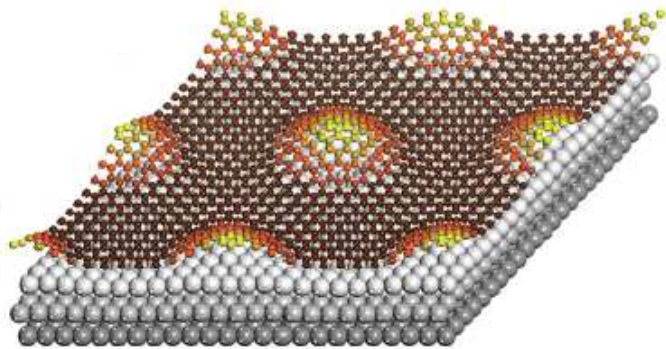
Graphene on TM surfaces

Gr/Ru(0001)



$\Delta h = 1.53 \text{ \AA}$

minimum Gr-Ru distance = 2.1 \AA



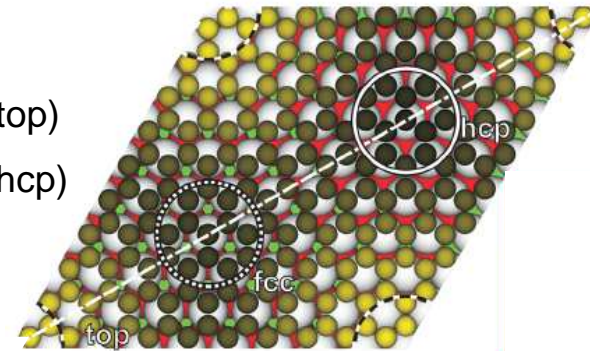
C(13x13)/Ru(12x12)

Gunther et al. PRL 104 (2010) 136102

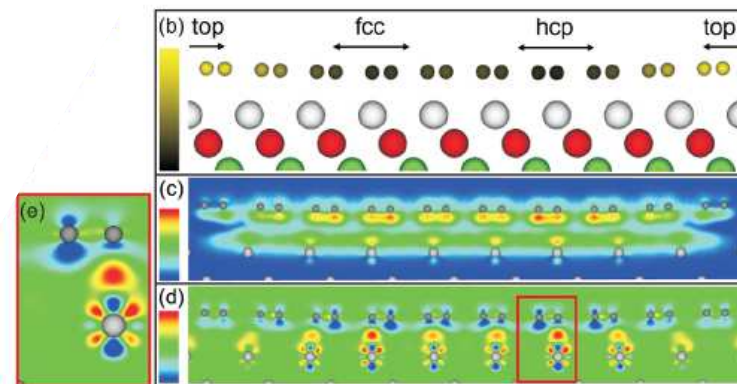
Gr/Ir(111)

DFT

- $h = 3.62 \text{ \AA}$ (top)
 - $h = 3.27 \text{ \AA}$ (hcp)
- $\Delta h = 0.35 \text{ \AA}$



C(10x10)/Ir(9x9)




SW $\Delta h = 0.6 \pm 0.1 \text{ \AA}$; $\Delta h = 1.0 \pm 0.2 \text{ \AA}$

Busse et al. PRL 107 (2011) 036101

Interaction between TM metals and graphene

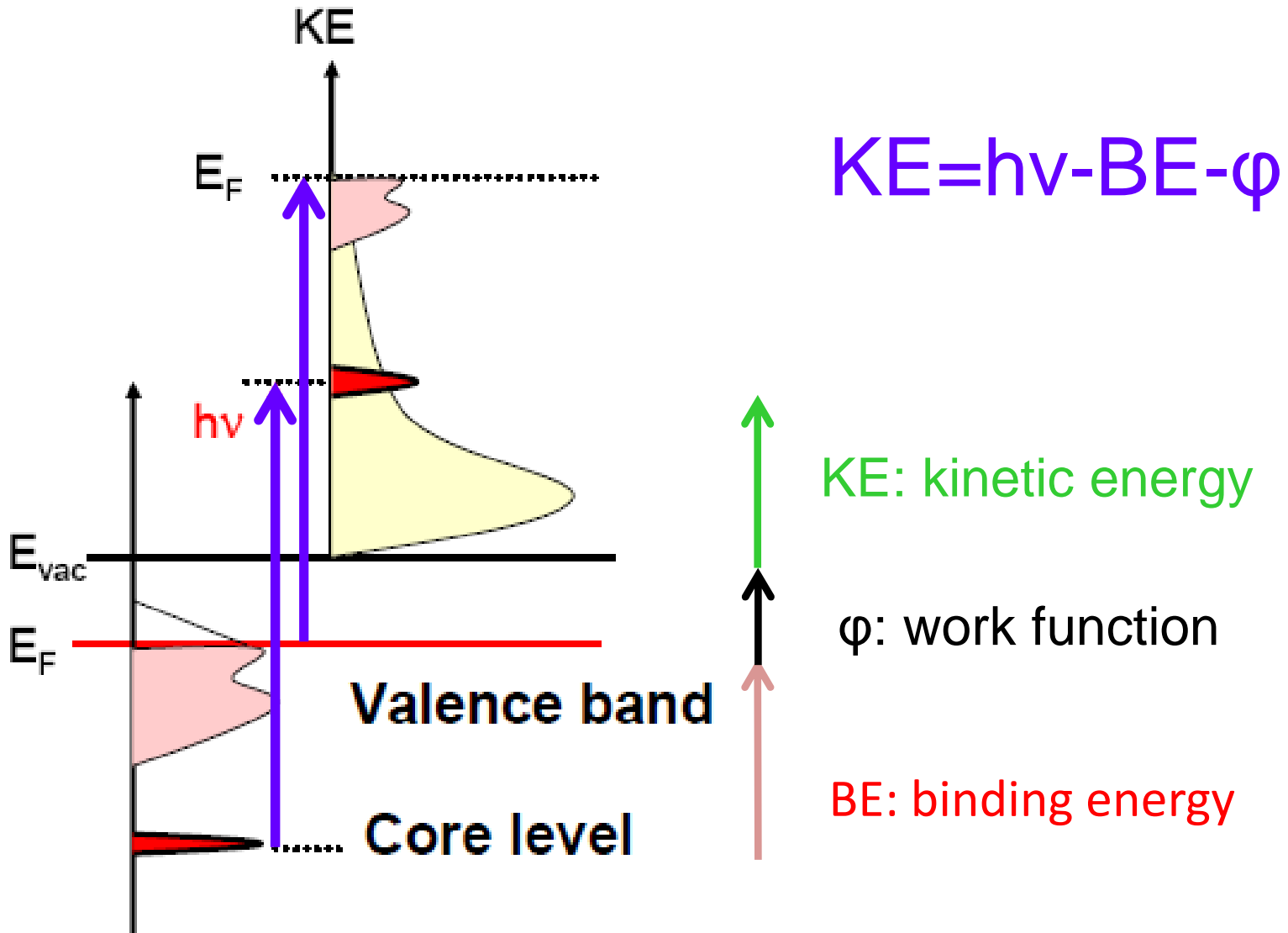
Ti carbide	V	Cr	Mn	Fe	Co ^S d=2.1 ^S c=0 π=?	Ni ^S d=2.1 ^S c=0 π=2.9V ^D	Cu ^M d=3(3.3) ^I c=? π=intact ^I
Zr	Nb	Mo	Tc	Ru ^S d=2.1,3.6 ^S c=1.6 ^D (0.82) ^S π=2.6mV ^I	Rh ^S d=2.2,3.8 ^I c=1.6 ^S π=?	Pd ^M d=2.6 ^I c=? π=?	Ag ^M d=3.3 ^V c=? π=intact ^W
Hf carbide	Ta carbide	W carbide	Re ^S d=2.1,3.8 ^S c=1.6 ^S π=?	Os	Ir ^{S/M} d=3.4-4 ^{I,1} c=0.3 ^I π=intact ^M	Pt ^M d=3.3 ^{I,1} c=? π=intact ^S	Au ^M d=3.3 ^E c=? π=intact ^V

 Gr may grow on the bulk carbide

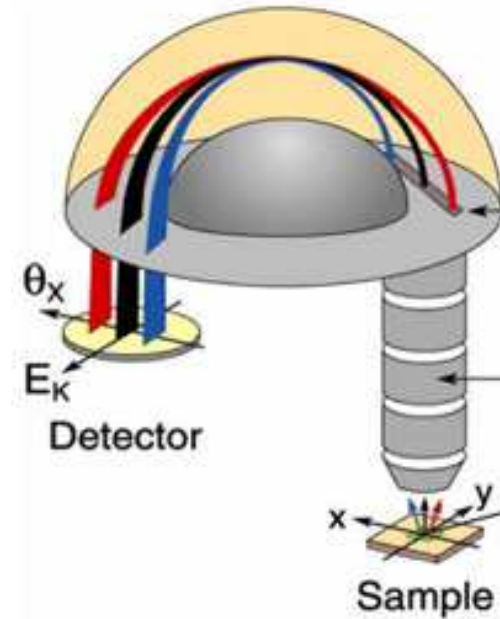
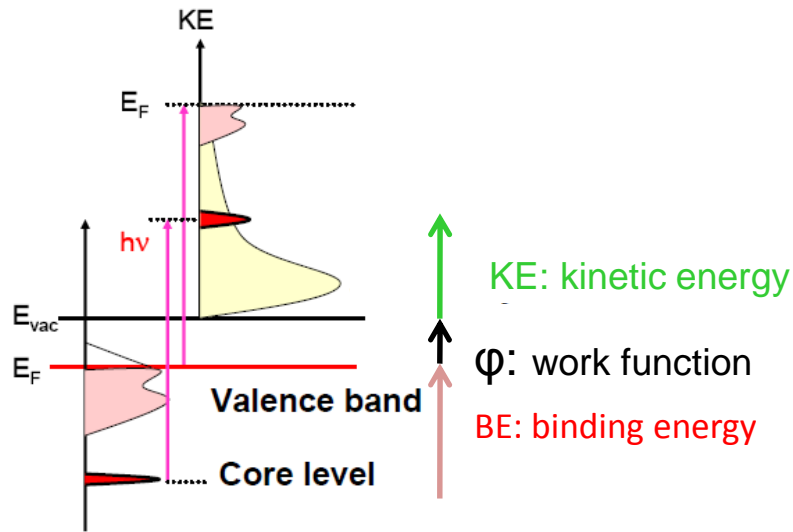
 strongly interacting with Gr

 weakly interacting with Gr

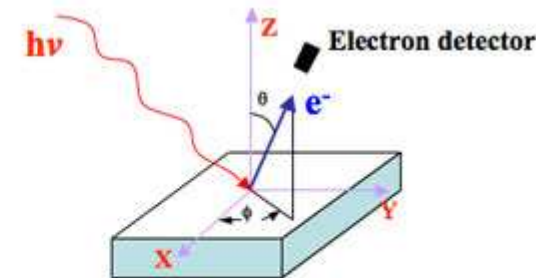
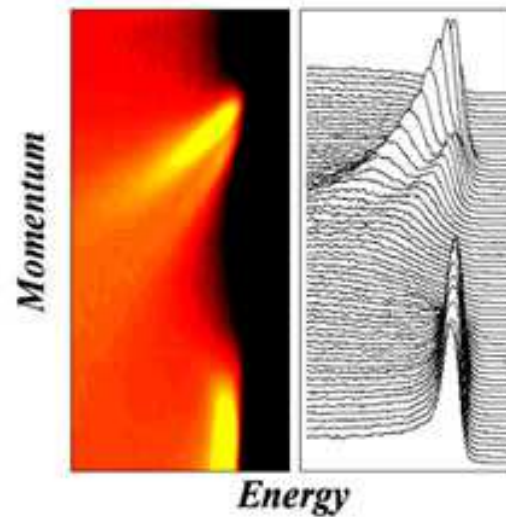
Angle resolved photoelectron spectroscopy (ARPES)



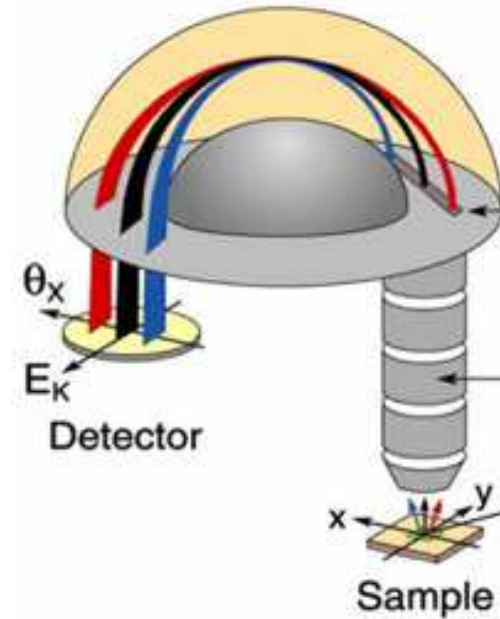
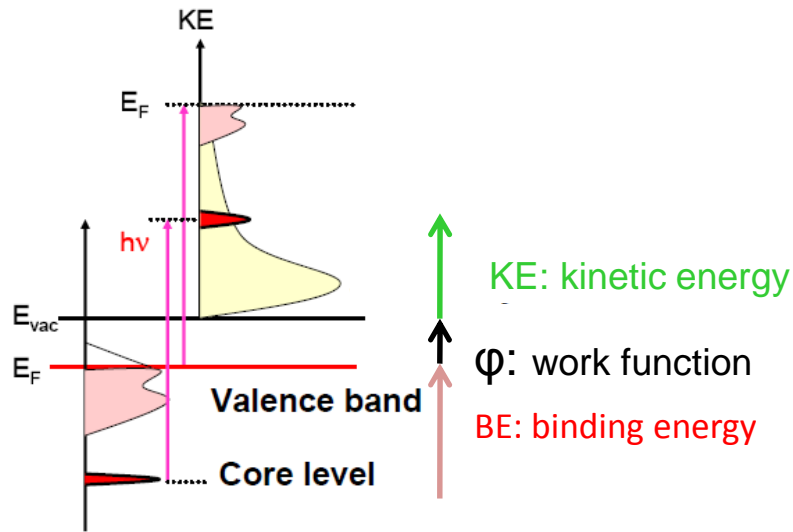
Angle resolved photoelectron spectroscopy (ARPES)



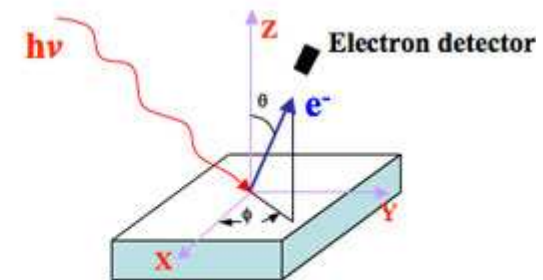
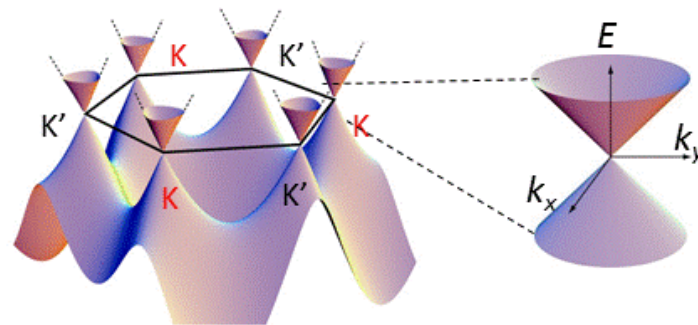
$$KE = h\nu - BE - \phi$$



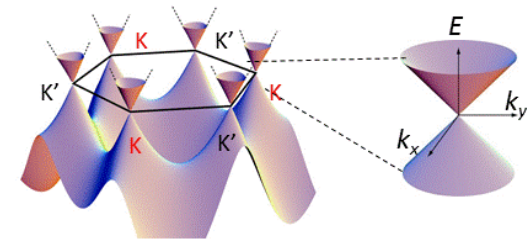
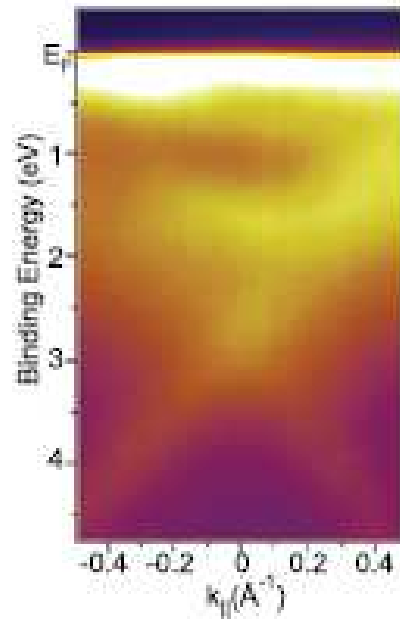
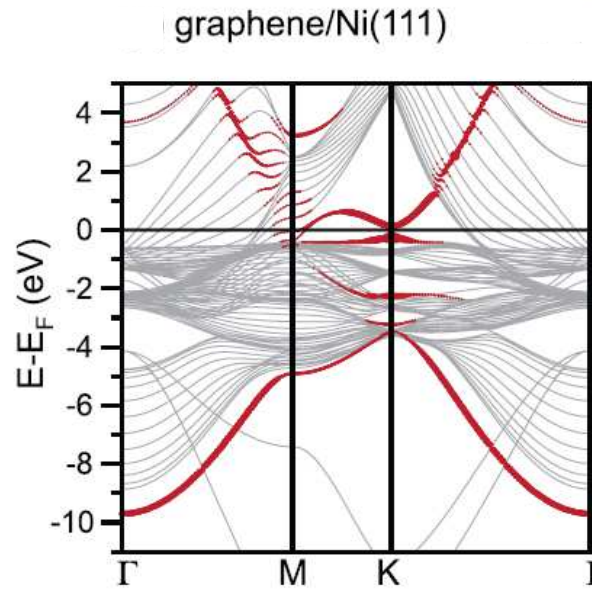
Angle resolved photoelectron spectroscopy (ARPES)



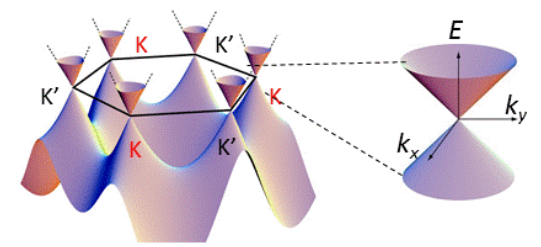
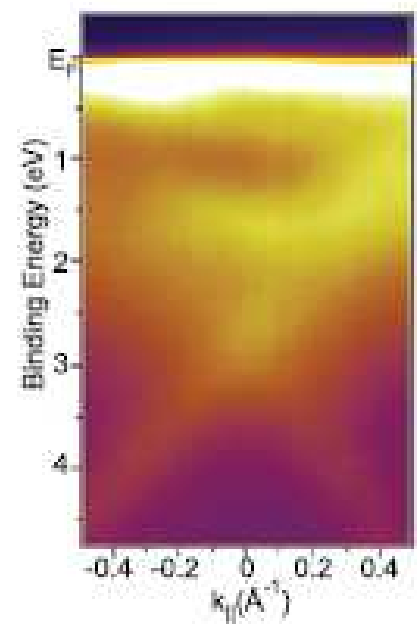
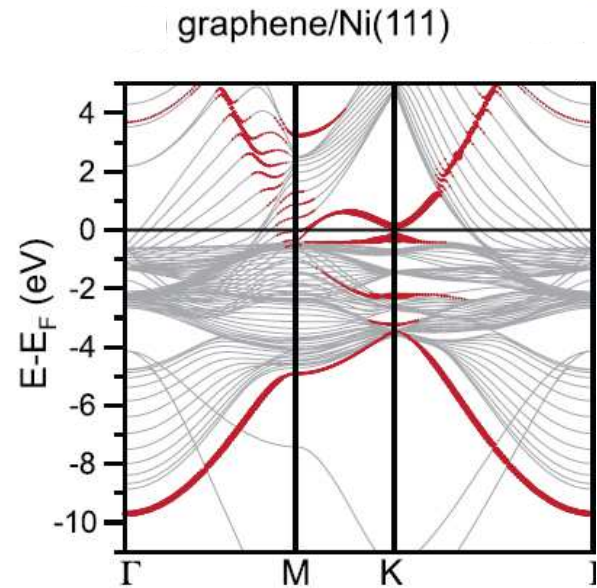
$$KE = h\nu - BE - \phi$$



Graphene/Ni(111)

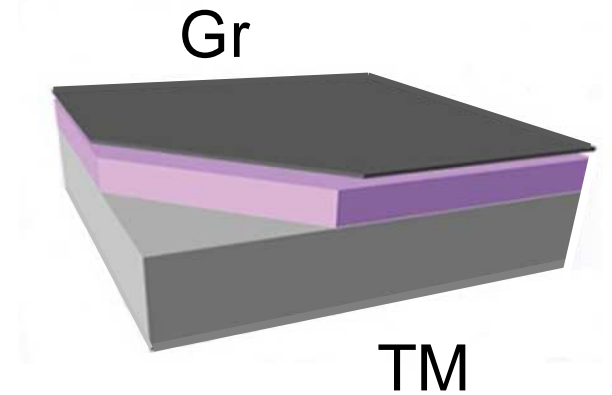
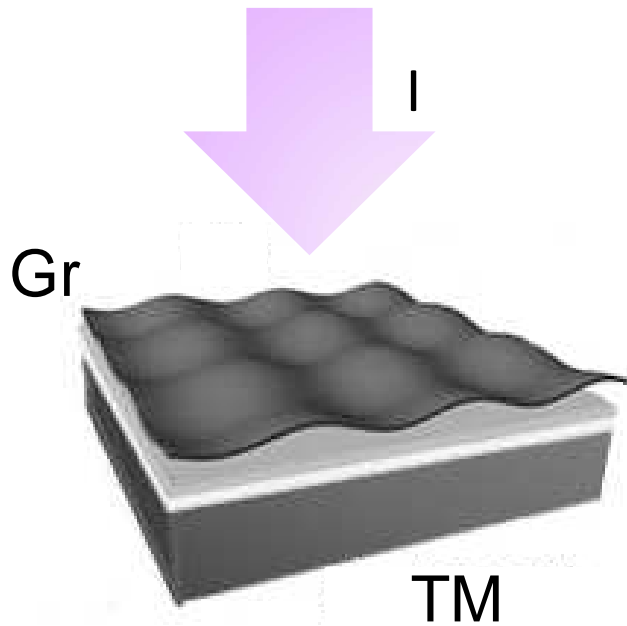


Graphene/Ni(111)



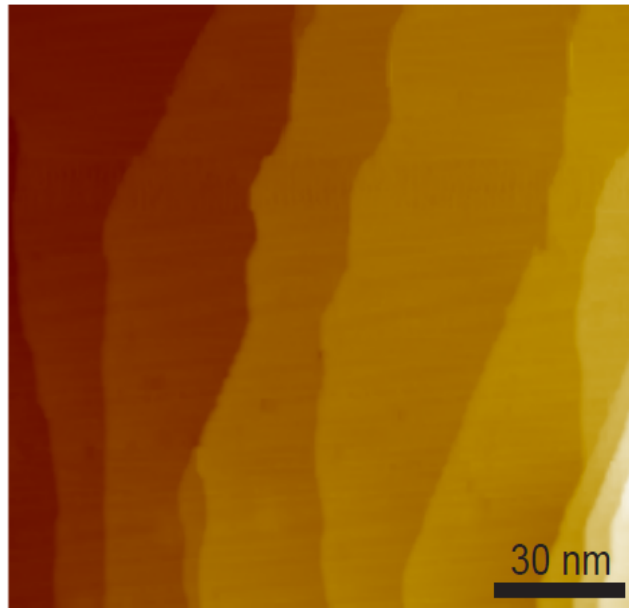
No Dirac cones: the interaction between graphene and the Ni(111) substrate is too strong

Intercalation of below epitaxial graphene

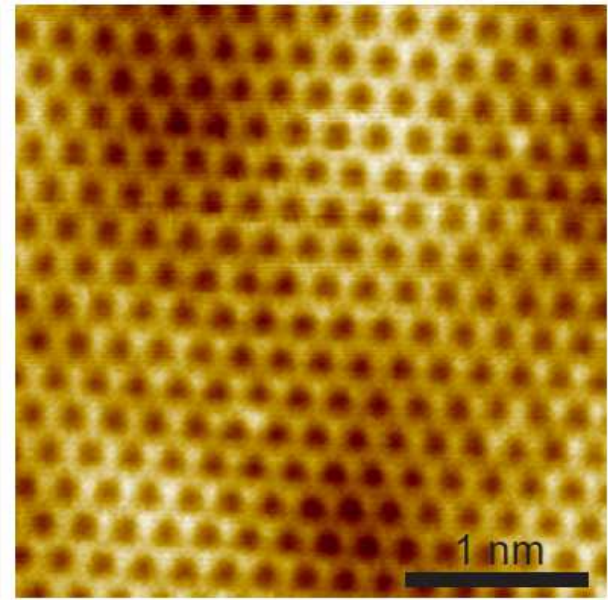


Decoupled graphene

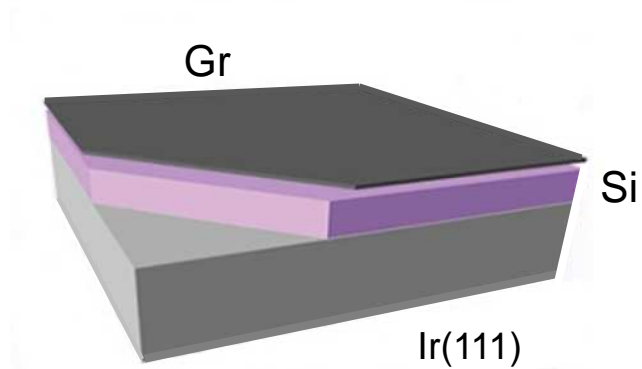
Scanning Tunneling Microscopy



Gr/Ir(111)

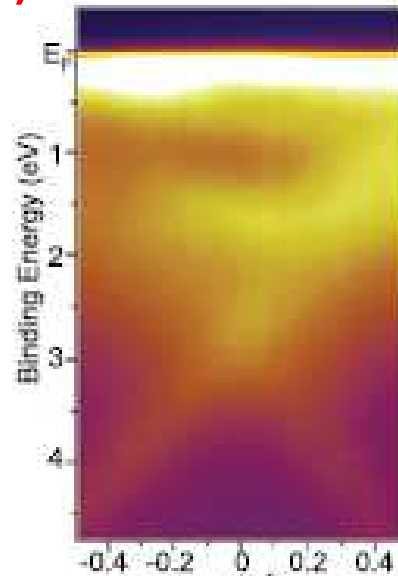
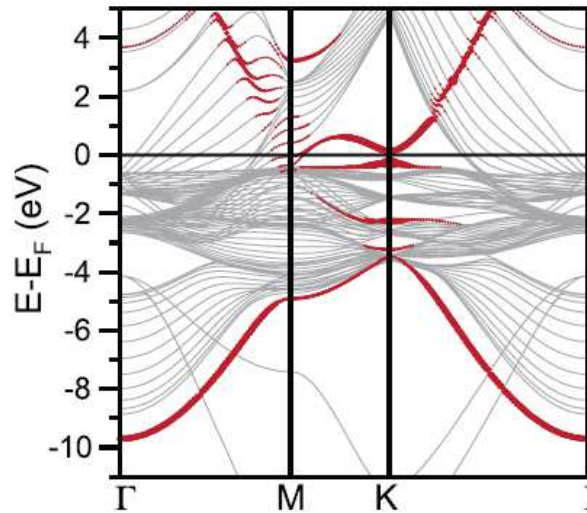


Gr/Si/Ir(111)

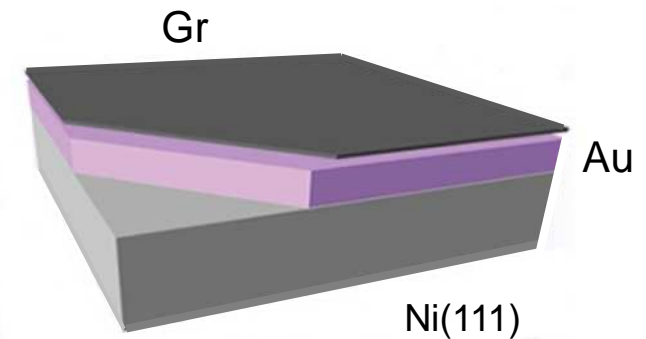
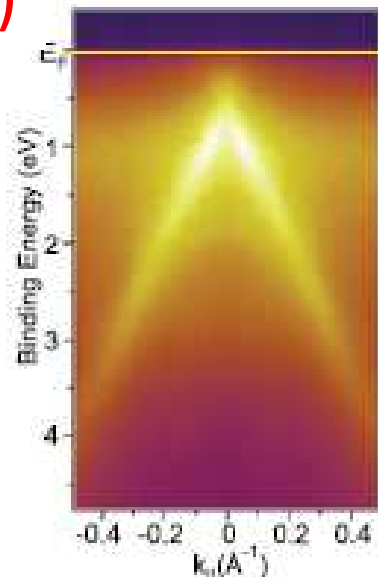
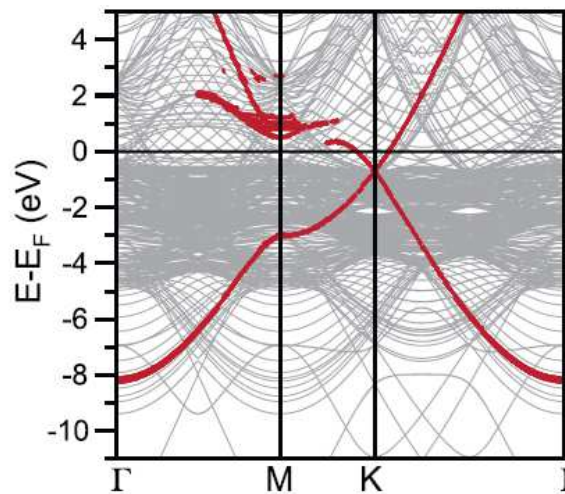


Decoupled graphene/Ni(111): Au intercalation

graphene/Ni(111)

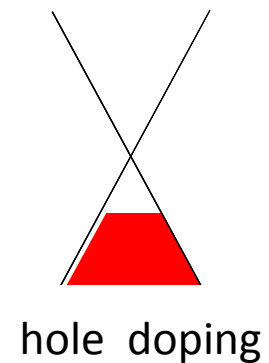
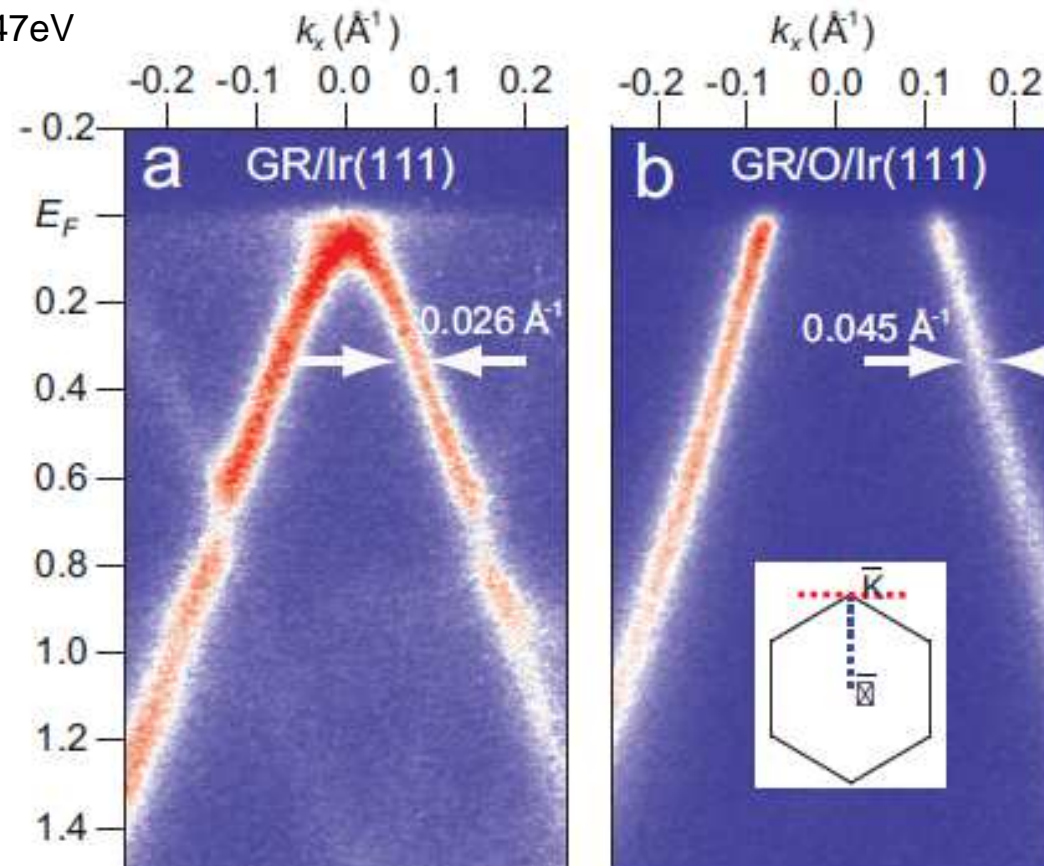


graphene/Au/Ni(111)



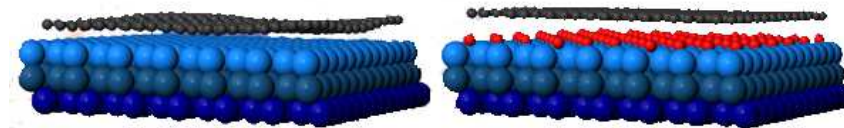
Decoupling of Gr from the Ir(111) substrate by O intercalation

ARPES $h\nu=47\text{eV}$



$E_D = -0.067 \text{ eV}$

$E_D = -0.64 \text{ eV}$



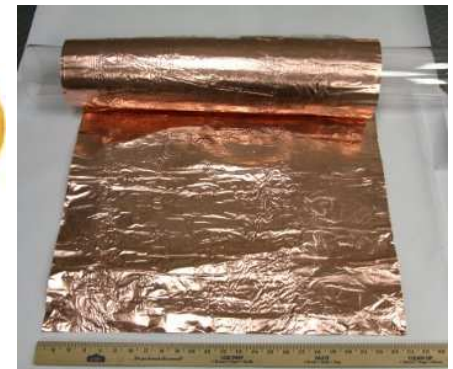
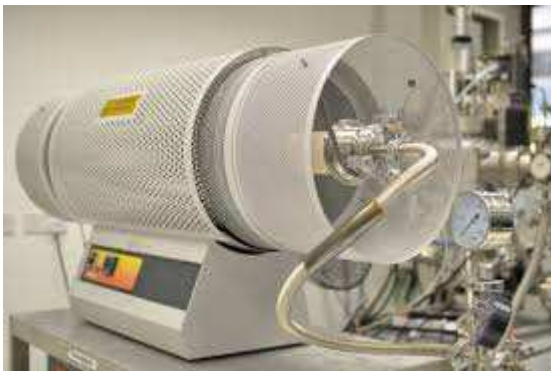
What we have learned :

- Graphene grows on reactive TM metal crystals
- The intercalation with the metal substrate changes the electronic structure of graphene
- Graphene can be decoupled from the substrate
- Atoms in contact to graphene might induce doping

If we want to move to technology.....

- Graphene grows on reactive TM metal ~~crystals~~
- The interaction with the metal substrate changes the electronic structure of graphene **weakly interacting metal**
- Graphene can be decoupled from the substrate 😊
- Atoms in contact to graphene might induce doping 😐

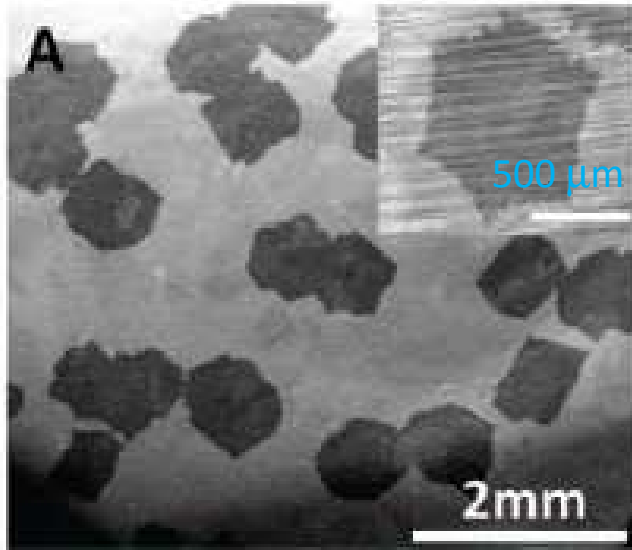
It is convenient to switch to a cheap substrate
polycrystalline copper foils WEAKLY reactive 😐



and use furnaces to grow large area graphene

Graphene growth on copper

oxygen-rich Cu

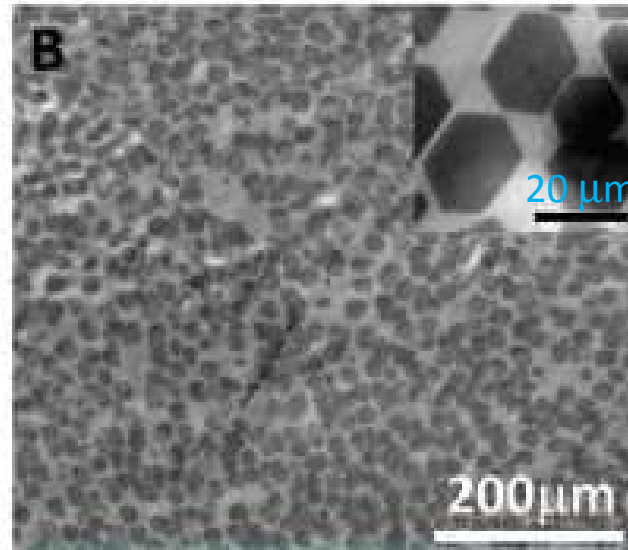


150 min

$p_{\text{CH}_4} = 1 \times 10^{-3}$ torr $p_{\text{H}_2} = 0.1$ torr

Low domain density
Dendritic edges

oxygen-free Cu



50 min

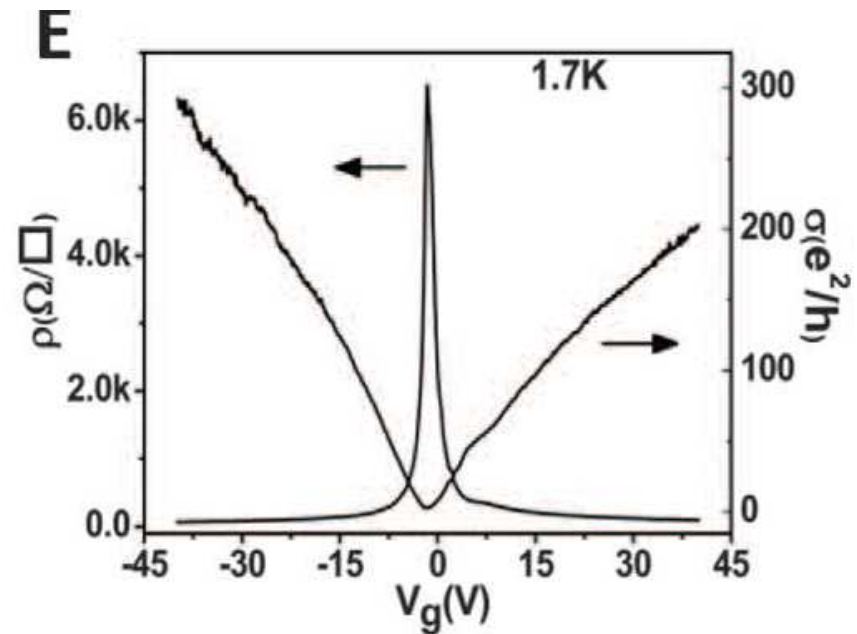
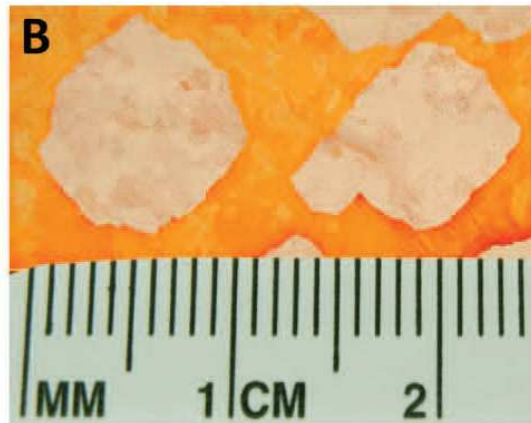
High domain density
Sharp edges

SEM

Hao et al. Science 2013

Graphene growth on copper

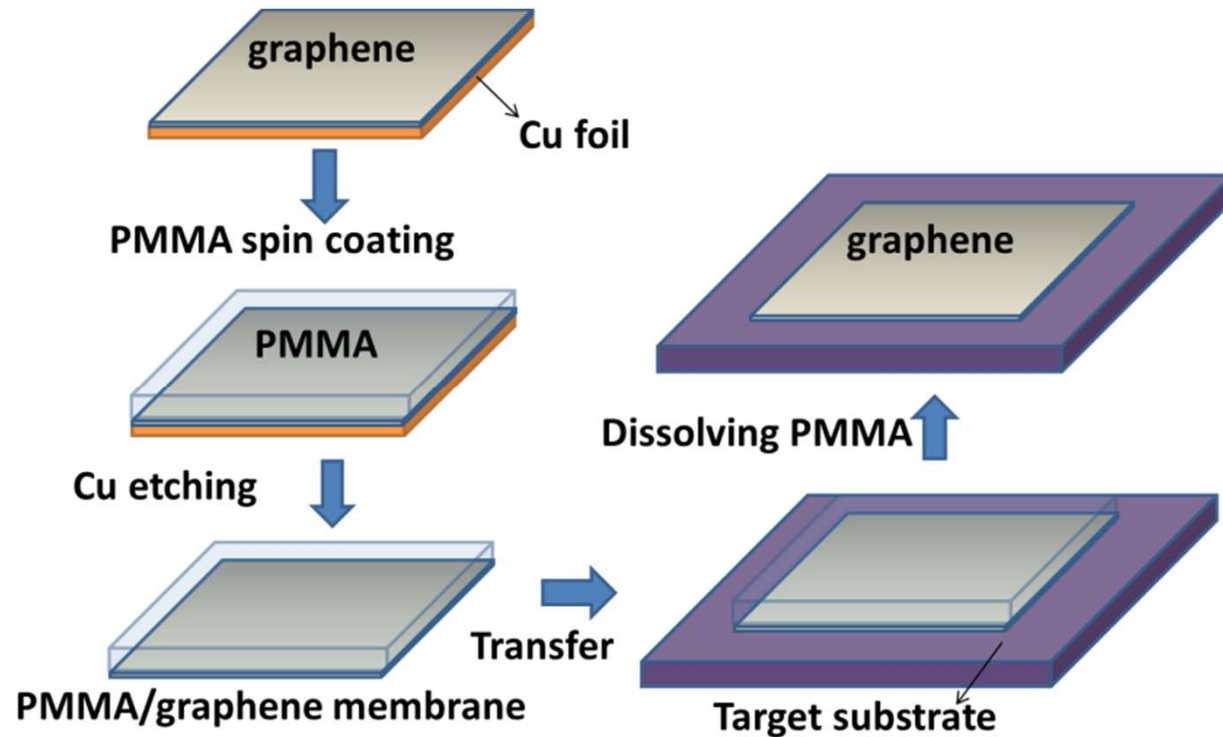
Carrier mobility 40.000-65.000 cm²/Vs (1.7 K)
15.000-30.000 m²/Vs (RT)



Hao et al. Science 2013

Electrical quality of large Gr domains is comparable to that of exfoliated graphene

Transfer of large area graphene



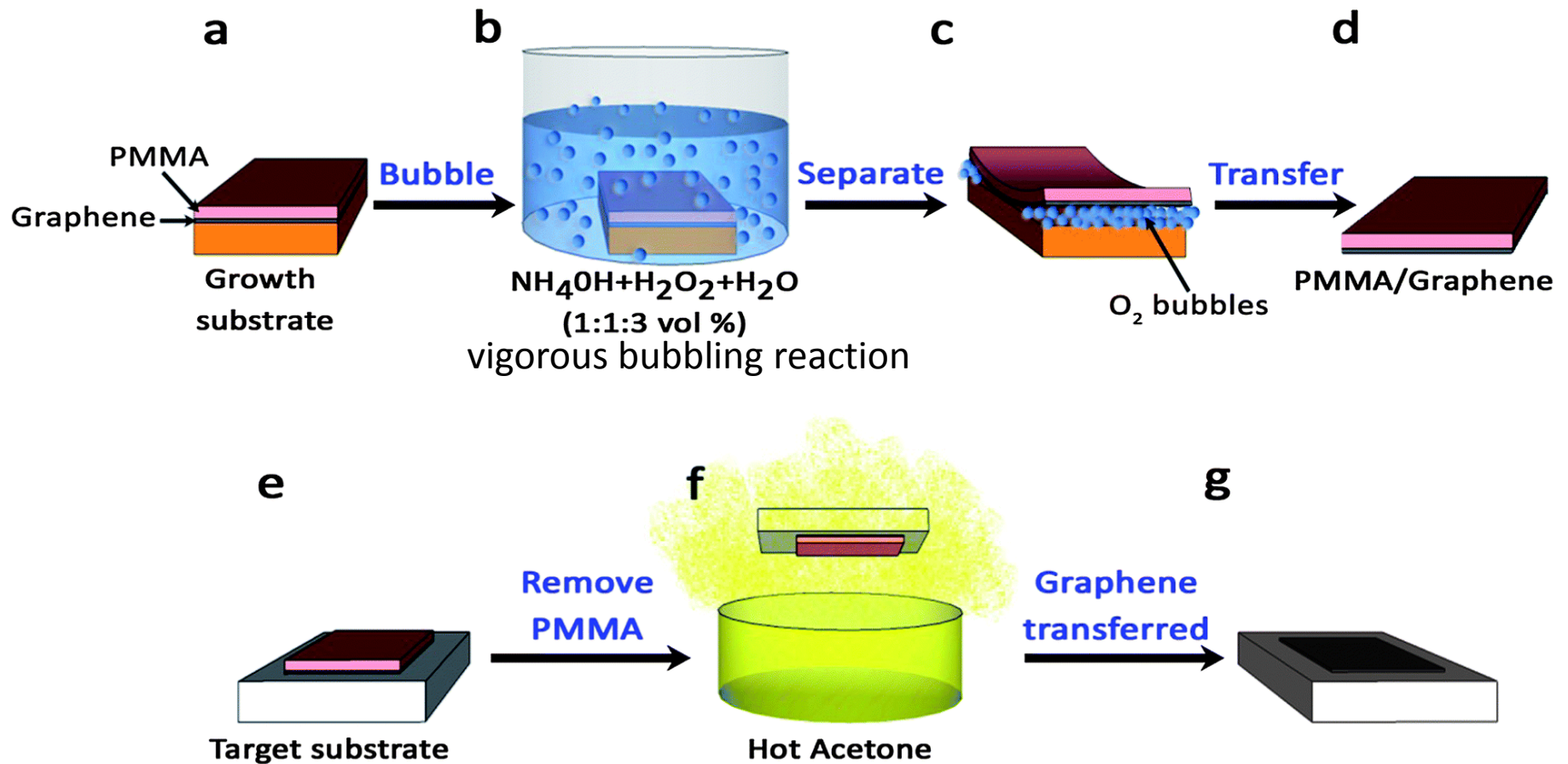
Ajay Kumar¹ and Chee Huei Lee²

Drawbacks:

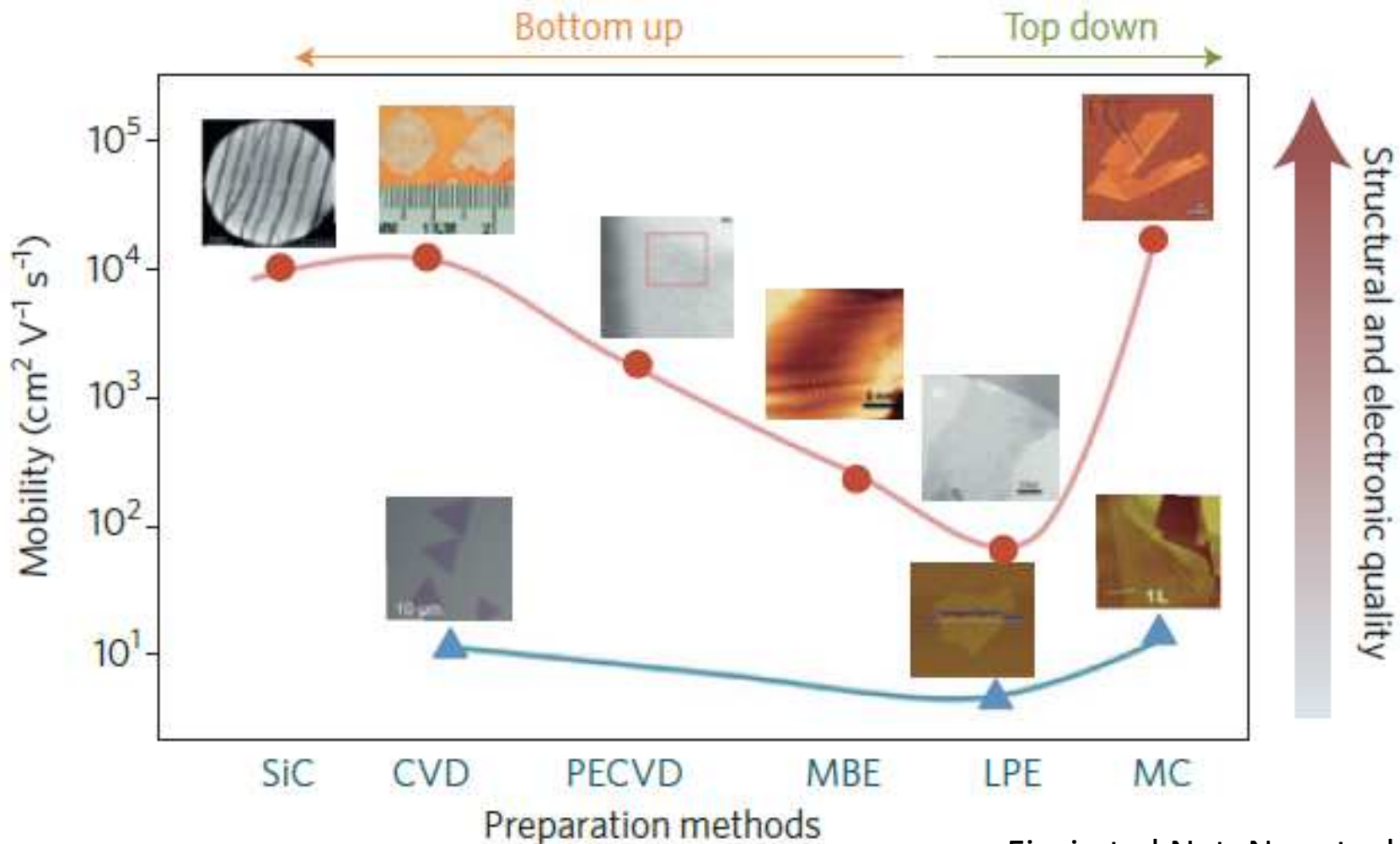
Structural defects , cracks, polymer residuals.

Additional processing: vacuum annealing, substrate treatment,...

Transfer of large area graphene



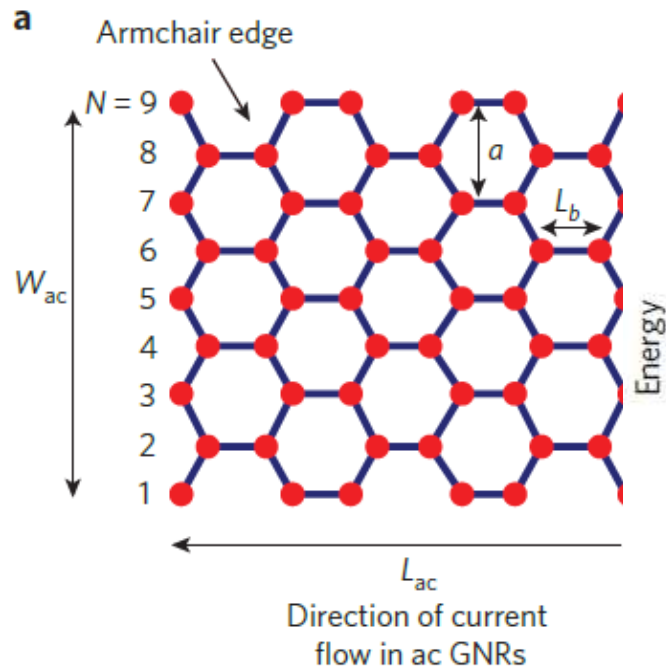
Mobility of 2DMs vs. preparation methods



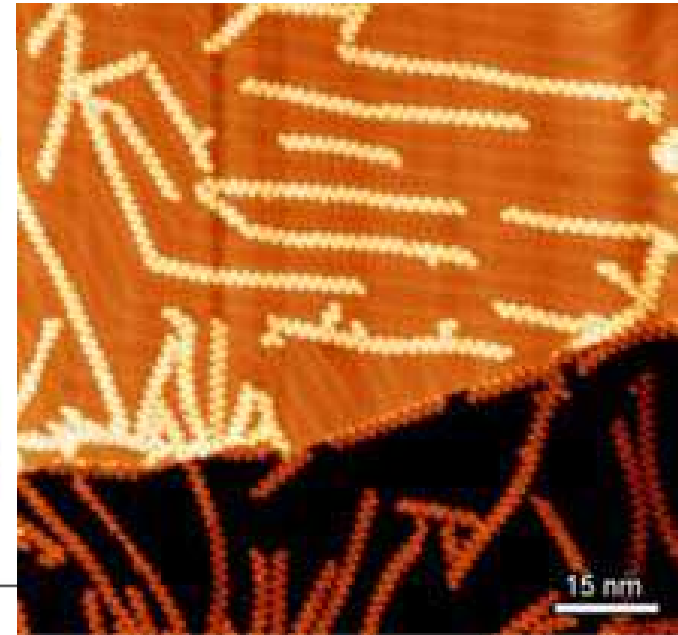
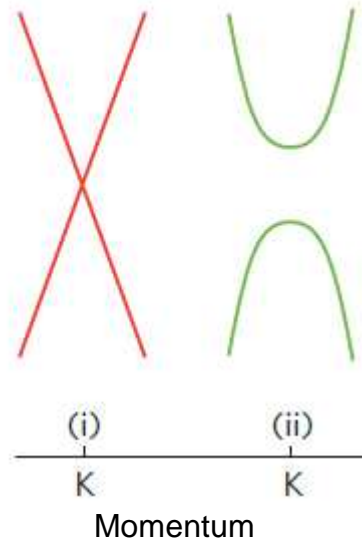
Fiori et al Nat. Nanotech 2014

Graphene grown at high T has a higher mobility than that grown at lower T.

Graphene nanoribbons



Schwartz Nat. Nanotech. 2010



1 nm wide, 50 nm long

J. Cai *et al*, *Nature*, 2010

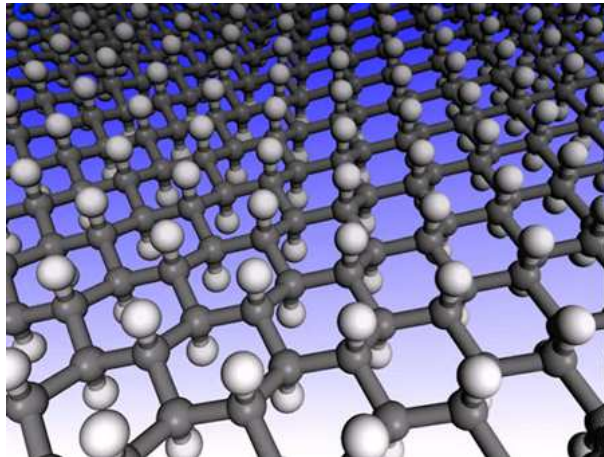
$$E_{\text{gap}} \sim 1.38/W \text{ eV}$$

carrier mobilities 50-200 cm^2/Vs

relative increase in edge scattering events of charge carriers in the GNRs.

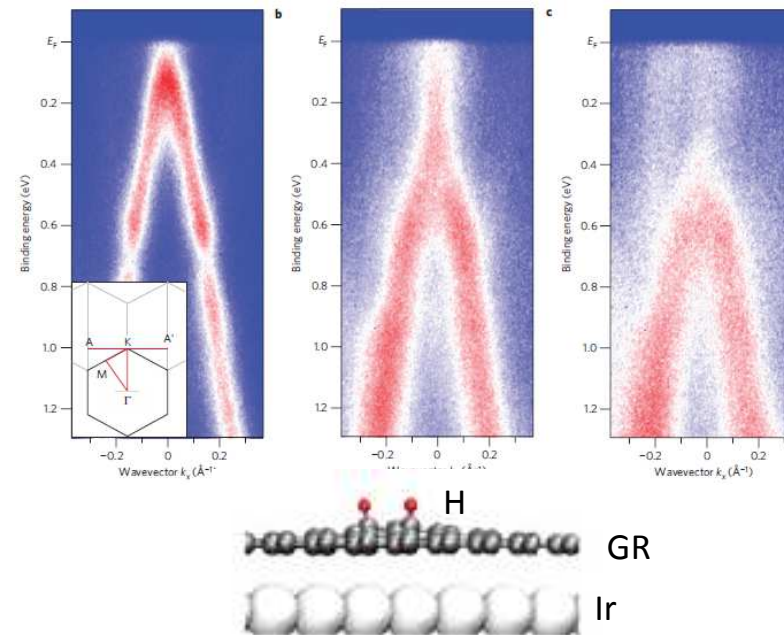
Graphane (CH)_n

*sp*³ bonds



graphane is a 2-D analog
of cubic diamond

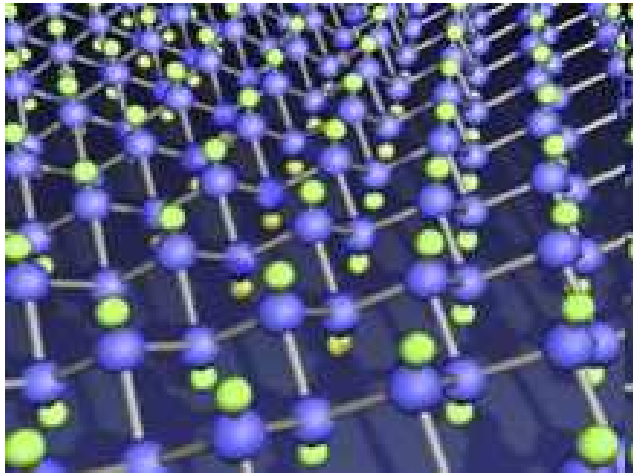
DFT calculations reveal that fully hydrogenated graphene is a wide-bandgap semiconductor, whereas half-hydrogenated graphene has a bandgap of 0.43 eV



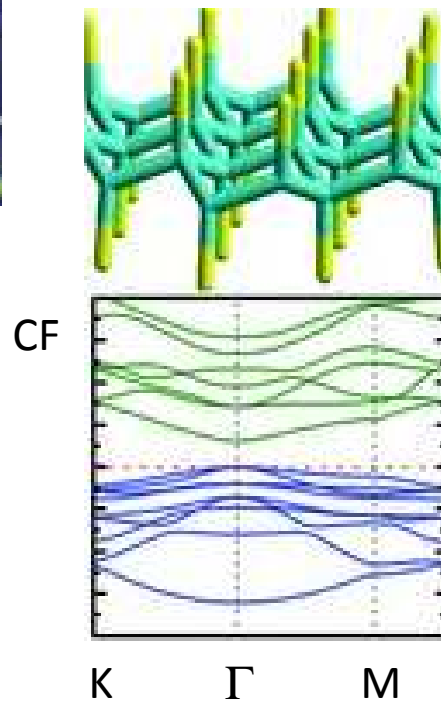
Balog et al. Nature mat. 9 (2010) 315

graphene hydrogenated from either one or both sides rapidly lost H at moderate *T*, which casts doubts that it could be used in applications where stability is required

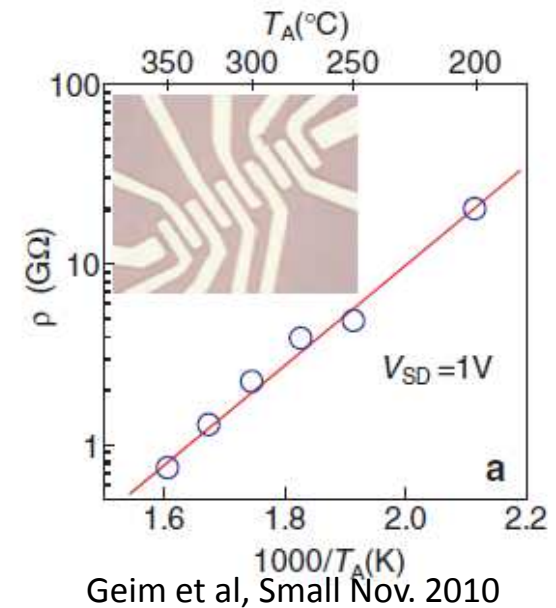
Fluorographene: the world's thinnest insulator



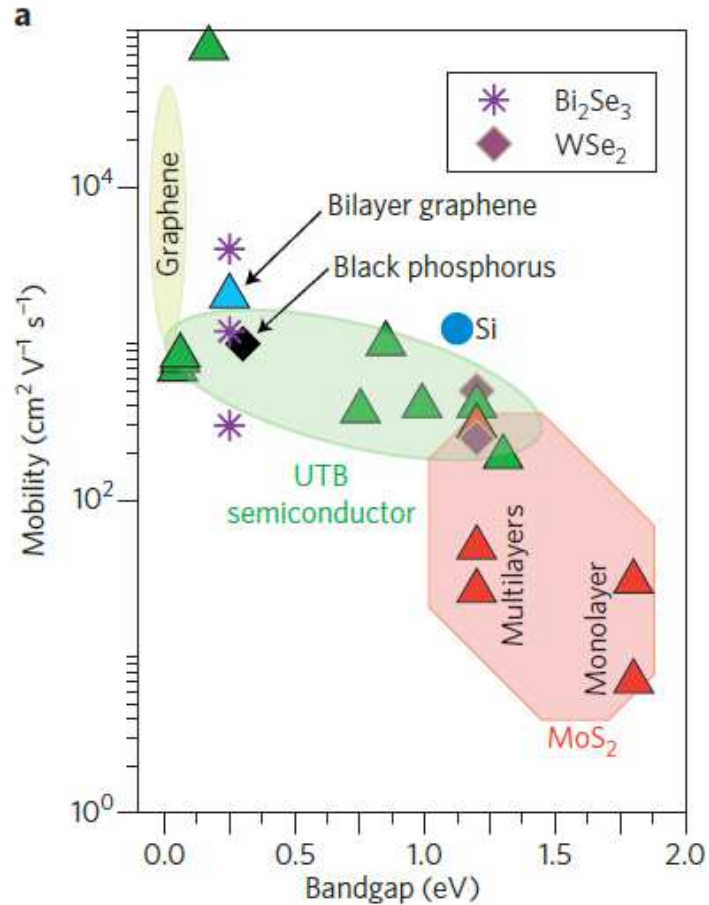
FG can be seen as a 2D analogue of Teflon, which is a fully fluorinated 1D carbon chain, or as a 2D counterpart of graphite fluoride.



Zboril et al Small, Nov. 2010



2D materials



Fiori et al Nat. Nanotech 2014

- New materials

2D layers of IV group elements:

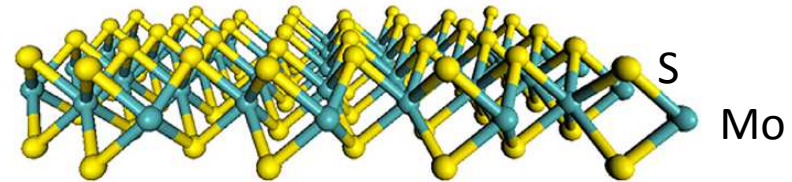
silicene, germanene, stannene

- Materials already known in their 3D form

Nitrides **h-BN**

Transition metal dichalcogenides (**MoS₂, WS₂**...)

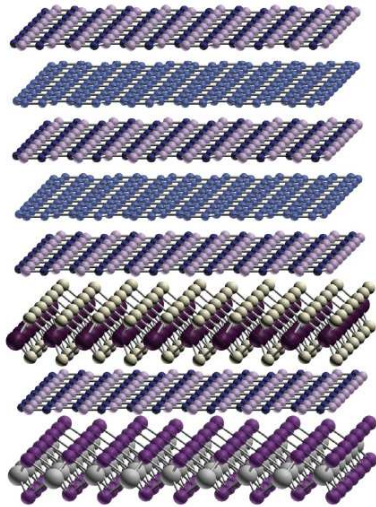
MX_2 (M: Mo, W, Nb, Re, Ni, or V) (X: S, Se, or Te)



Oxides **MoO₃, V₂O₅**

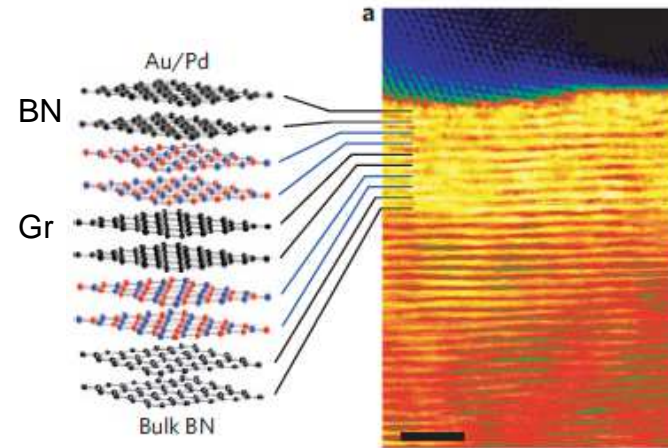
Phosphorene

2D materials



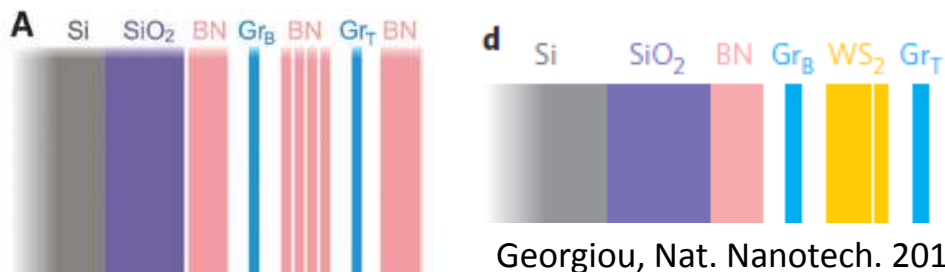
K. S. Novoselov, Rev. Mod. Phys. 83, 837 2011

Graphene-based superlattices



S. Haigh et al. Nat. Mat. 11 764 (2012)

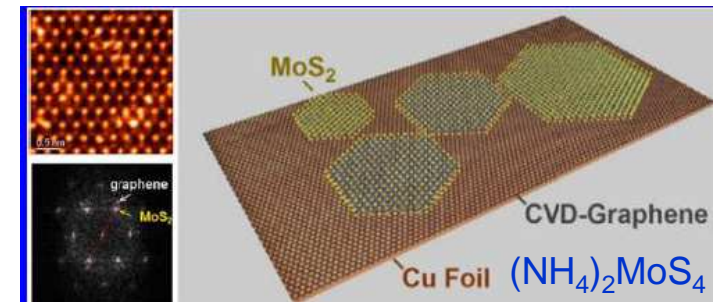
Field-Effect Tunneling Transistor Based on Vertical Graphene Heterostructures



Georgiou, Nat. Nanotech. 2012

Britnell et al. Science 335, 947 (2012)

van der Waals Epitaxy of MoS₂ Layers on graphene



Shi et al. Nano Lett. 2012, 12, 2784

Conclusions

- Growth of large area high-quality, single-crystal 2D materials , required for the practical realization of 2D material-based technologies and for high-volume manufacturing, is a **challenging tasks**.
- With respect to graphene, 2D materials (monolayer and few-layer films) growth processes are still in their **infancy**, and many groups around the world are investigating ways of producing them (control of thickness, purity and point defects, such as chalcogen vacancies).
- Another crucial point in the fabrication of electronic devices is related to the **electric contact** between 2D materials and metals, which needs to be ohmic and have low resistance.
- Before these production processes can be used in any high-volume manufacturing environment, **the growth conditions that yield high-quality films need to be stablished and optimized**.
- If large-area materials growth is successful, 2D material technology could enable a new generation of **flexible electronics** for wearable and bendable systems.



GRAPHENE FLAGSHIP

launched in 2013, 10 years, budget of €1 billion

142 academic and industrial research groups 23 countries

The Graphene Flagship is tasked with bringing together academic and industrial researchers to take graphene from the realm of academic laboratories into European society, thus generating economic growth, new jobs and new opportunities.



GRAPHENE FLAGSHIP

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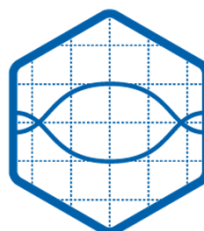
WP 1:
Materials



WP2:
Health and
Environment



WP3:
Fundamental
Science



WP4:
High Frequency
Electronics



WP 5:
Optoelectronics



WP6:
Spintronics



WP7:
Sensors



WP8:
Flexible
Electronics



WP10:
Nanocomposites



WP9:
Energy



WP11:
Production



WP 12:
Innovation



Thanks for your attention!